

Optimisation du facteur de mérite : l'exemple des oxydes de cobalt

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UMR6508 CNRS et ENSICAEN

GDR Thermoélectricité, Nancy, juillet 2009



Plan de l'exposé

- **Introduction : comment augmenter ZT?**

- ↳ **Nanostructuration**

- Augmentation du facteur de puissance
+ réduction de la conductivité thermique

- ↳ **Réduction de la conductivité thermique**

- ↳ **Corrélations électroniques**

- Augmentation du facteur de puissance

- **Les oxydes de cobalt
à structure lamellaire désaccordée**

$$ZT = \frac{S^2 T}{\rho \kappa} = \frac{S^2 T}{\rho(\kappa_e + \kappa_l)}$$

- **Formule de Mott** : $S = \frac{\pi^2 k_B^2}{3e} T \left(\frac{\partial \ln \sigma(E)}{\partial E} \right)_{E=E_F}$

$$\sigma(E) = en(E) \mu(E)$$

S dépend de n(E), et de la position de E_F

- **Résistivité** : $\rho^{-1} = en(E)\mu(E)$

Forte mobilité

- **Conductivité thermique**

Terme électronique lié à ρ⁻¹ (Wiedemann Franz)
Terme de réseau à minimiser

$$ZT = \frac{S^2 T}{\rho \kappa} = \frac{S^2 T}{\rho(\kappa_e + \kappa_l)}$$

'PGEC'

Phonon glass – Electron crystal

Découplage électrons – phonons?

G. Slack, *Handbook of Thermoelectricity* (1995)

Facteur de puissance

Modification de DOS

↳ Nanostructuration

↳ Corrélations électroniques

Conductivité thermique

phononique

↳ 'Rattling'

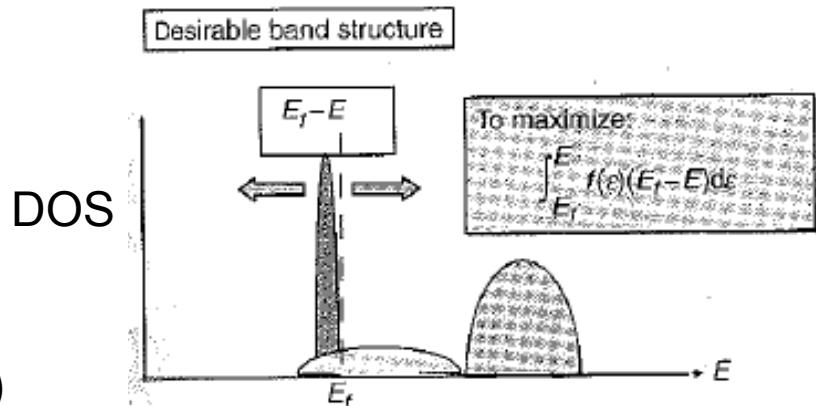
↳ Nanostructuration

Nanostructuration

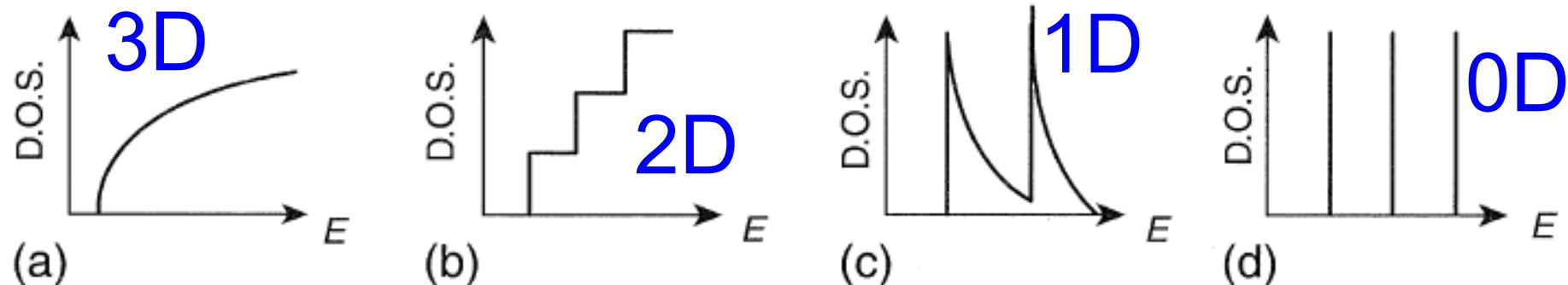
Formule de Mott

$$S = \frac{\pi^2 k_B^2}{3e} T \left(\frac{\partial \ln \sigma(E)}{\partial E} \right)_{E=E_F}$$

Tse et al., *Handbook of Thermoelectricity* (2006)



Nanostructuration



modification de la DOS
↳ **augmentation de S**

Hicks et Dresselhaus, PRB47, 12727 (1993)
Hicks et Dresselhaus, PRB47, 16631 (1993)

Superréseaux $\text{Bi}_2\text{Te}_3/\text{Sb}_2\text{Te}_3$

$ZT = 2.5!$

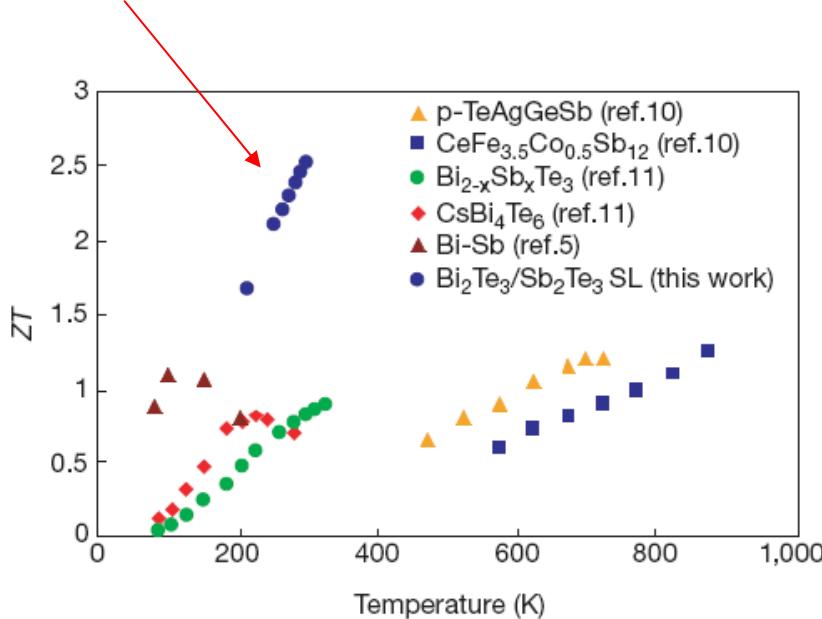


Figure 3 Temperature dependence of ZT of 10Å/50Å p-type $\text{Bi}_2\text{Te}_3/\text{Sb}_2\text{Te}_3$ superlattice compared to those of several recently reported materials.

Venkatasubramanian et al., *Nature*
413, 597 (2001)

Diffusion des phonons aux interfaces

Venkatasubramanian, PRB61, 3091 (2000)

Amélioration de la mobilité
+
Réduction de κ_L

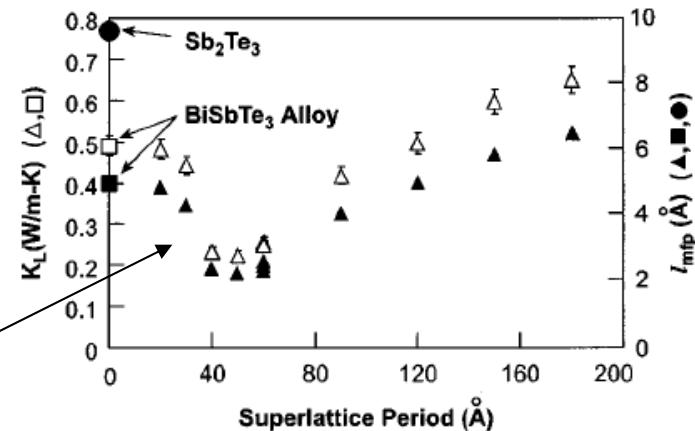


FIG. 3. Experimental lattice thermal conductivity (K_L) and calculated average phonon mean free path (l_{mfp}) as a function of the period in $\text{Bi}_2\text{Te}_3/\text{Sb}_2\text{Te}_3$ superlattices and other reference materials. Note: There are three data points, almost on top of each other, at the 60 Å period, corresponding to 30 Å/30 Å, 10 Å/50 Å, 20 Å/40 Å structures.

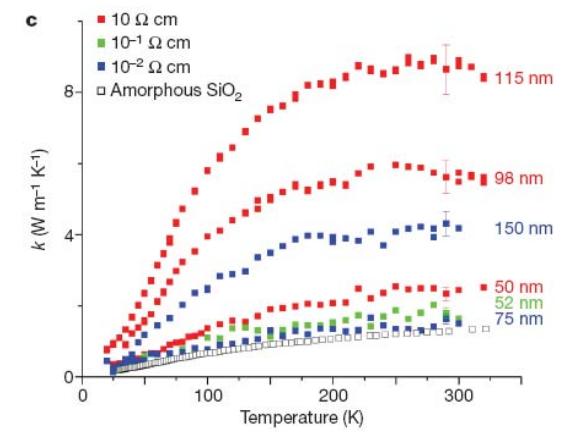
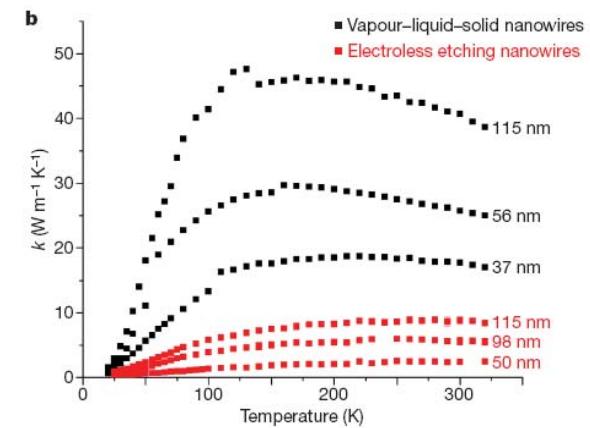
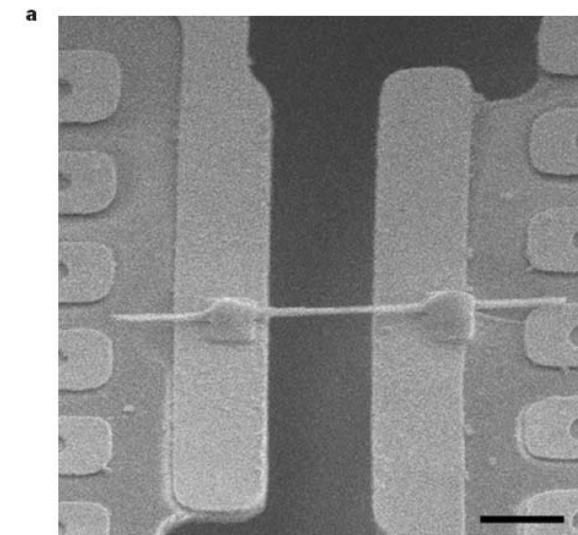
Nanofils de silicium

A. I. Hochbaum et al., Nature 451, 163 (2008)
A. I. Boukai et al., Nature 451, 168 (2008)

Si : ZT ~ 0.01 à 300K

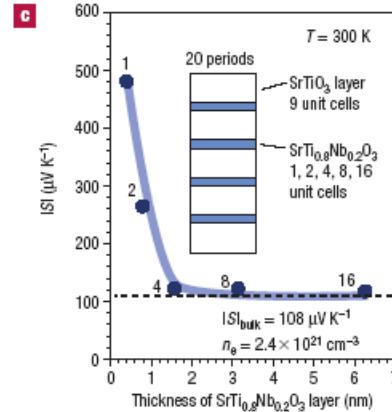
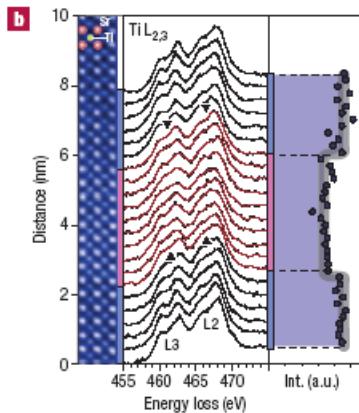
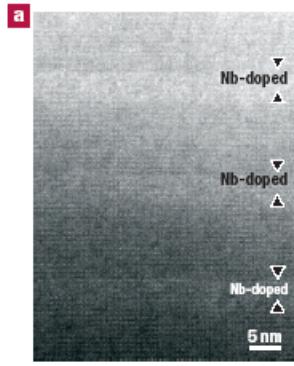
↳ ZT = 0.6 à 300K
pour les nanofils

Effet principalement lié aux
Phonons :
réduction de κ + phonon drag pour S



2D electron gas in SrTiO₃

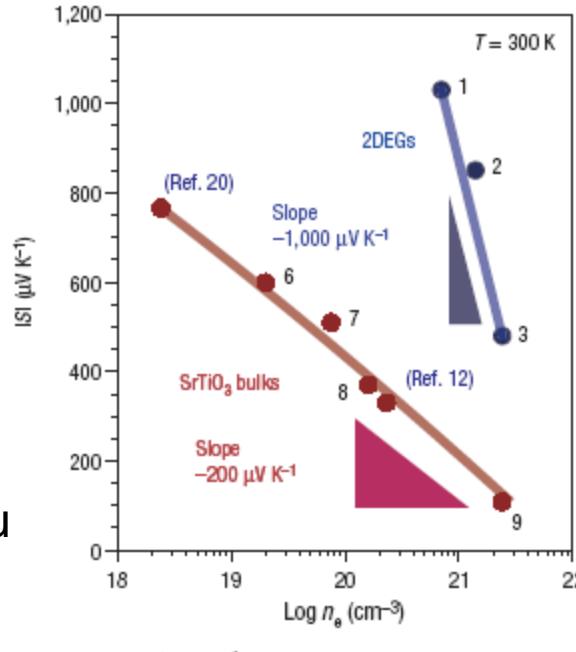
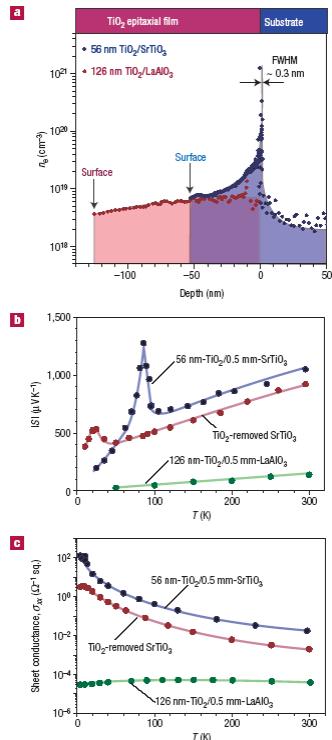
H. Ohta et al., Nat. Mater. 6, 129 (2007)



Nanostructuration :
Augmentation de S

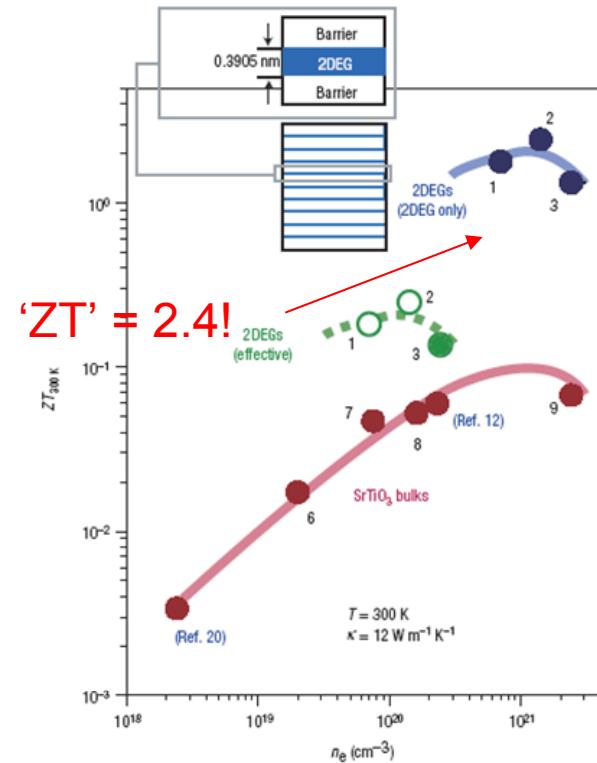
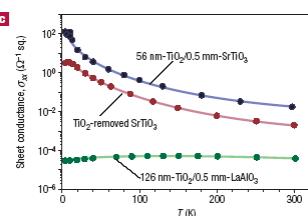
$$\sigma_{\text{eff.}} = \sigma_{\text{2DEG}} / (1 + N_{\text{barrier}})$$

$$ZT_{\text{eff.}} = ZT_{\text{2DEG}} / (1 + N_{\text{barrier}})$$



$$|S| = -k_B/e \cdot \ln 10 \cdot A \cdot (\log n_e + B)$$

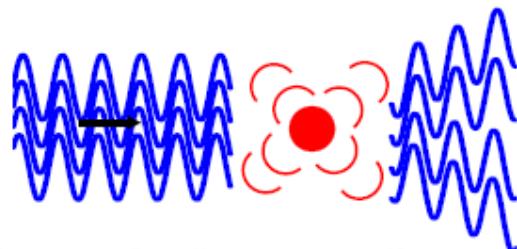
Pic de S lié au phonon drag



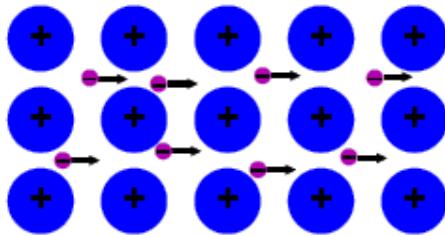
κ mesuré sur monocristal de SrTiO₃

Réduction de la conductivité thermique ‘Phonon glass’

Phonon glass / Electron crystal



“Phonon glass” $\rightarrow \kappa$ small



“Electron crystal” $\rightarrow \sigma$ large

- Atomes lourds dans des cages (‘rattling’)
- Structures cristallines complexes
- Solutions solides
- Matériaux composites
Diffusion sur les défauts ponctuels
Diffusion par les joints de grains
- Nanostructures

Nanograins $\text{Si}_{95}\text{Ge}_5$ dopés P

Increased Phonon Scattering by Nanograins and Point Defects in Nanostructured Silicon with a Low Concentration of Germanium

G. H. Zhu,¹ H. Lee,² Y. C. Lan,¹ X. W. Wang,¹ G. Joshi,¹ D. Z. Wang,¹ J. Yang,¹ D. Vashaee,³ H. Guilbert,¹ A. Pillitteri,¹ M. S. Dresselhaus,⁴ G. Chen,^{2,*} and Z. F. Ren^{1,*}

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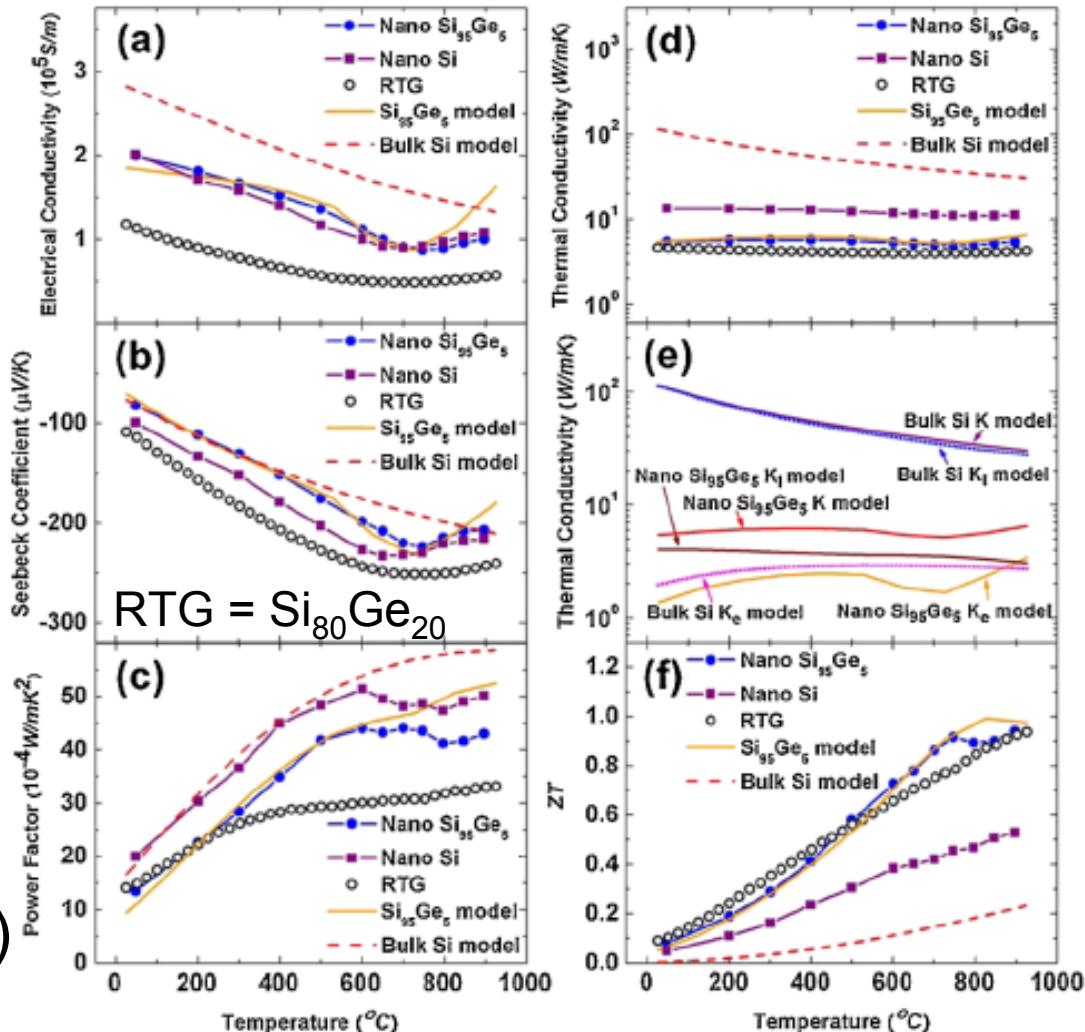
Cambridge, Massachusetts 02139, USA

(Received 26 November 2008; published 14 May 2009)

Faible composition en Ge :
bonnes propriétés
électriques (moins de
diffusion pour les électrons
et bonne solubilité du P)

Nanograins (5 -20nm) :
diffusion liée aux interfaces

Ge : responsable de
diffusion sur des défauts
ponctuels (phonons $\lambda < 1\text{nm}$)



Nanostructuration : WSe₂ et superréseaux

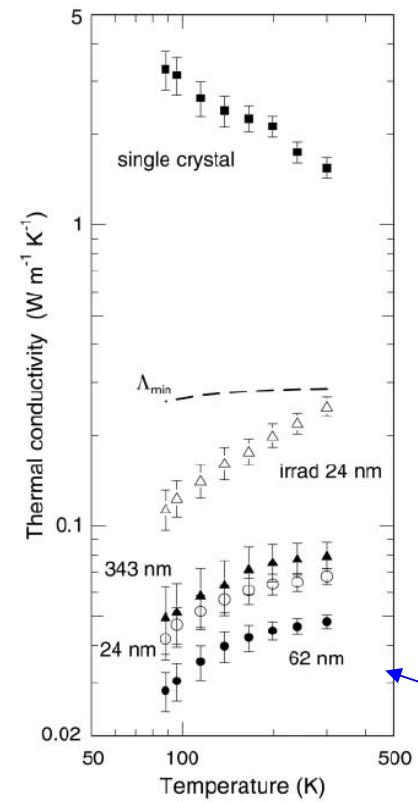
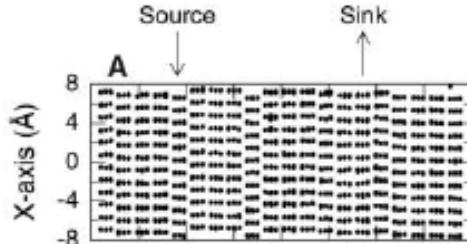


Fig. 2. Summary of measured thermal conductivities of WSe₂ films as a function of the measurement temperature. Each curve is labeled by the film thickness. Data for a bulk single crystal are included for comparison. Error bars are the uncertainties propagated from the various experimental parameters used to analyze the data (6). The ion-irradiated sample (irrad) was subjected to a 1-MeV Kr⁺ ion dose of $3 \times 10^{15} \text{ cm}^{-2}$. The dashed line marked Λ_{\min} is the calculated minimum thermal conductivity for WSe₂ films in the cross-plane direction.

Couches W/Se₂



Défauts d'empilement

→ réduction de κ

0.05Wm⁻¹K⁻¹
à 300K!

Modification
artificielle des
empilements

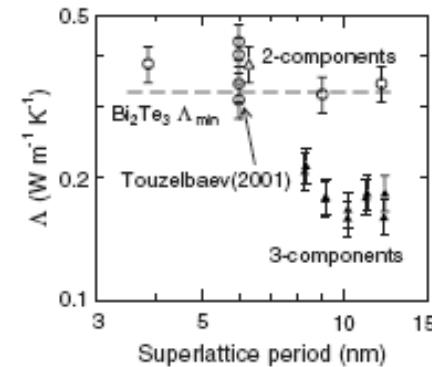


FIG. 2. Cross-plane thermal conductivity of three-component Bi₂Te₃/TiTe₂/Sb₂Te₃ films (filled triangle) and two-component Bi₂Te₃/Sb₂Te₃ films (open triangle) annealed at 250 °C. Open circles are thermal conductivities for Bi₂Te₃/Sb₂Te₃ superlattices in Ref. 25. Minimum thermal conductivity for Bi₂Te₃ (dashed line) was calculated using the model in Ref. 26 and is included for comparison.

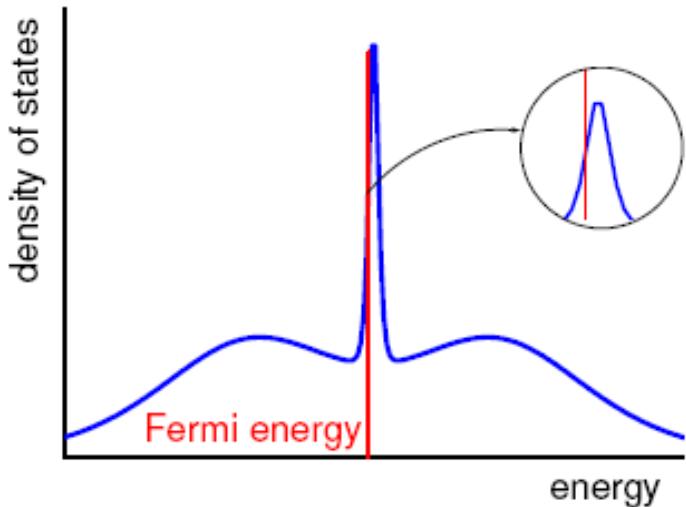
Facteur de puissance en cours d'étude

Corrélations électroniques

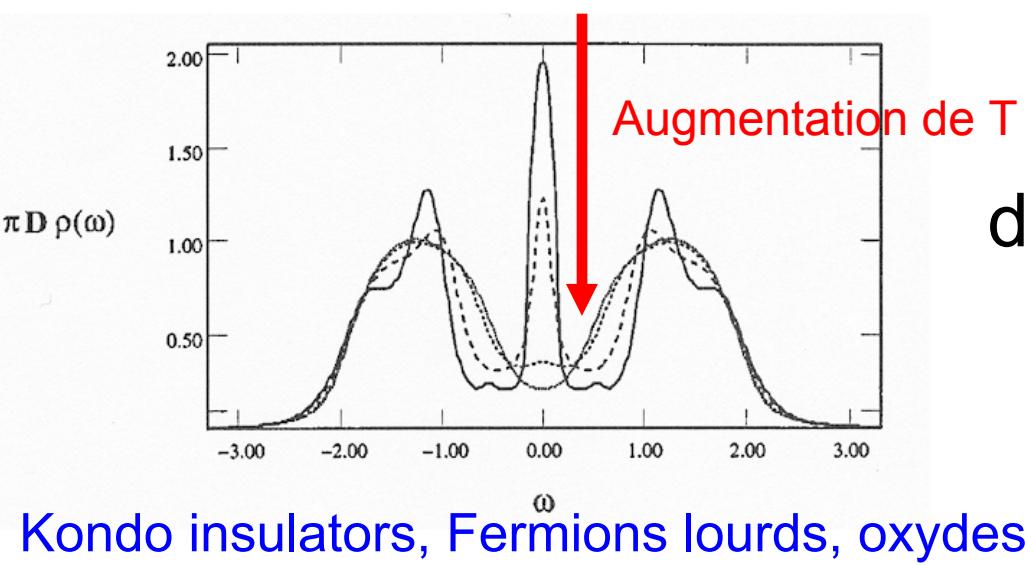
Terme diffusif

Terme haute T (formule de Heikes)

Corrélations électroniques



Modification de
DOS liée aux
corrélations



Dépend
de U (énergie de répulsion
coulombienne),
de T

Kondo insulators, Fermions lourds, oxydes...

A. Georges et al, Review of Modern Physics 68, 13 (1996)

Augmentation de S liée aux corrélations électroniques

$$S = \frac{\pi^2 k_B^2}{3e} T \left(\frac{\partial \ln \sigma(E)}{\partial E} \right)_{E=E_F}$$

$$C_{el}/T = \gamma = \frac{\pi^2}{3} k_B^2 N(E_F)$$

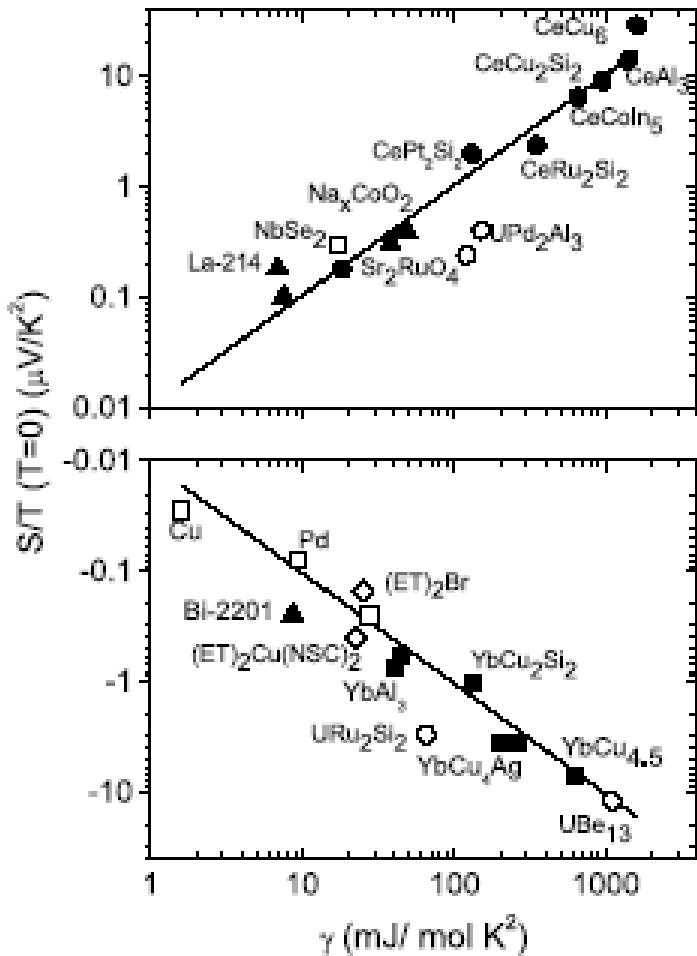
Rapport : S / chaleur spécifique C_{el}

Limite $T \rightarrow 0$

$$q = \frac{S}{T} \frac{N_{AV} e}{\gamma} = \text{cste}$$

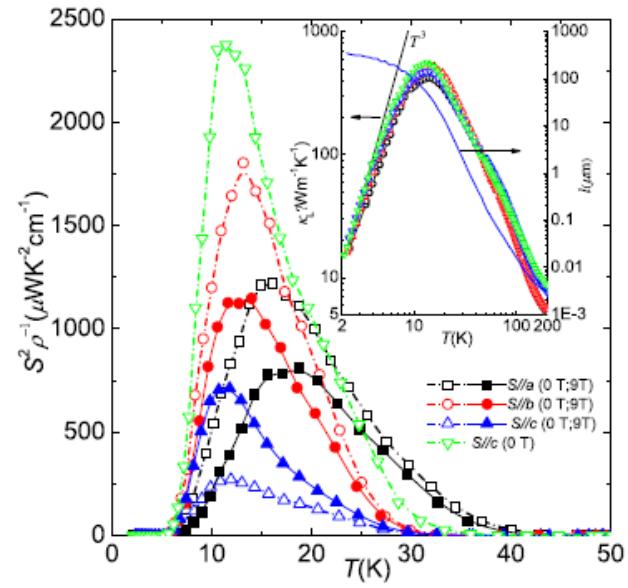
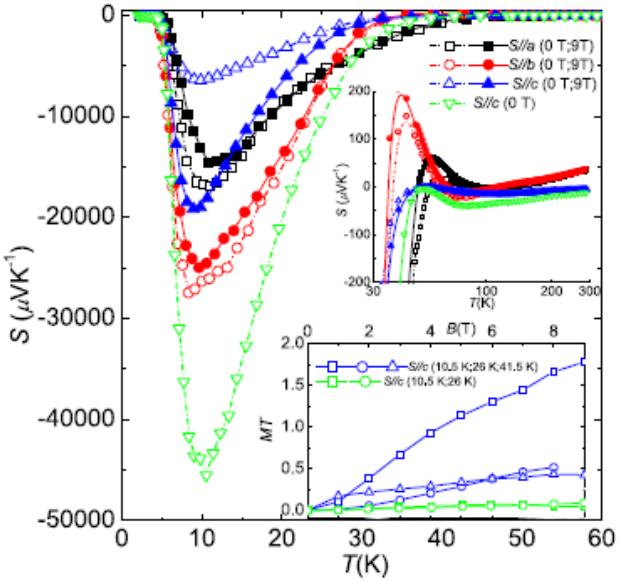
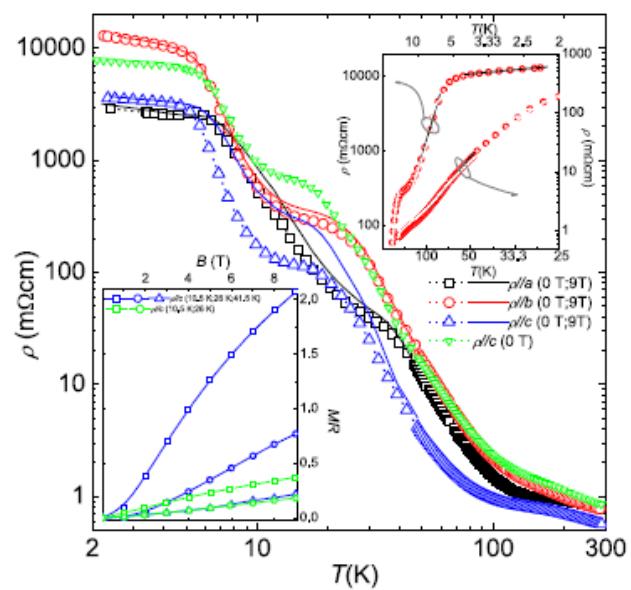
γ : partie électronique de la chaleur spécifique

$$0.5 < |q| < 2$$



'Strongly correlated semiconductor FeSb₂'

A. Bentien et al., EPL80, 17008 (2007)



Comparaison avec RuSb₂, isostructural :

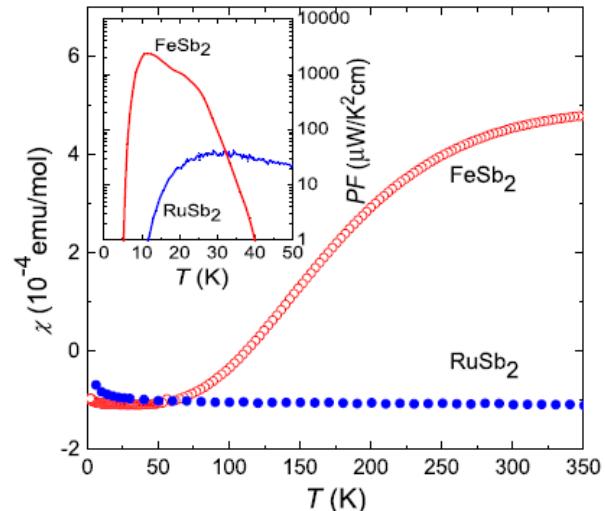
Pas d'effet de phonon drag (pas observé dans RuSb₂)

Terme diffusif *10 lié aux corrélations électroniques

P. Sun et al., PRB79, 153308 (2009)

Effet similaire observé dans FeSi

N. E. Sluchanko et al., EPL51, 557 (2000)



Modèle de Hubbard

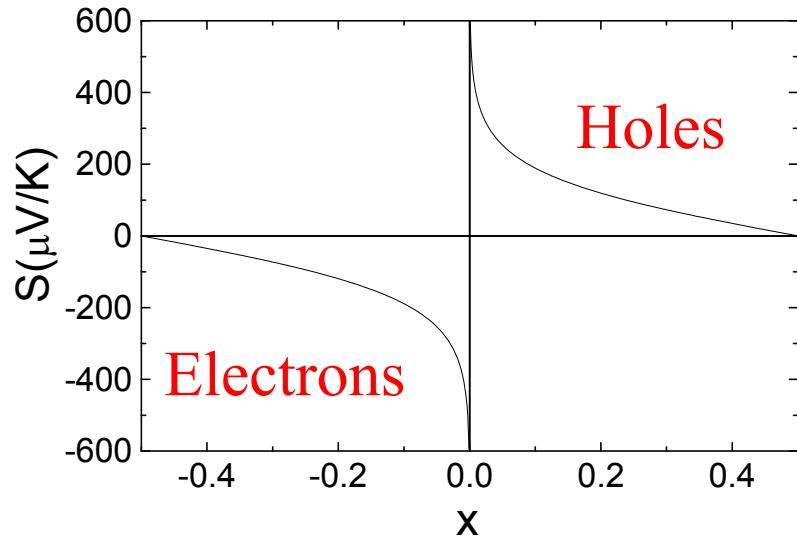
$$S = \frac{-S^{(2)} / S^{(1)} + \mu / |e|}{T} \rightarrow \frac{\mu / |e|}{T} \quad \text{for } T \rightarrow \infty$$

$S^{(1)}, S^{(2)}$: depends on v and Q , velocity and energy operators
Valid for narrow band systems with strong interactions

Limit $T \rightarrow \infty$: $S \sim \text{entropy} / \text{carrier}$

$$S = \frac{-k_B}{|e|} \ln\left(\frac{1-x}{x}\right)$$

x = carrier concentration

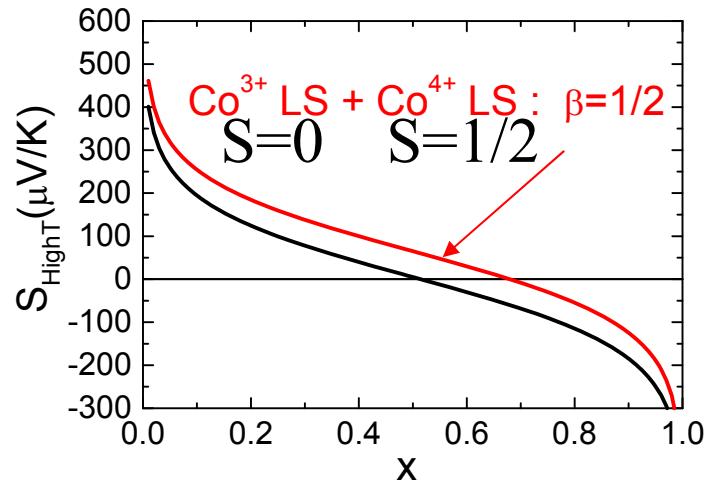


Entropie de spin

Terme supplémentaire de dégénérescence de spin
dans la formule de Heikes

Pour un cation à valence mixte $M^{n+} / M^{(n+1)+}$: $\beta = \frac{2S_n + 1}{2S_{n+1} + 1}$

$$S = -\frac{k_B}{|e|} \ln(\beta \frac{1-x}{x})$$

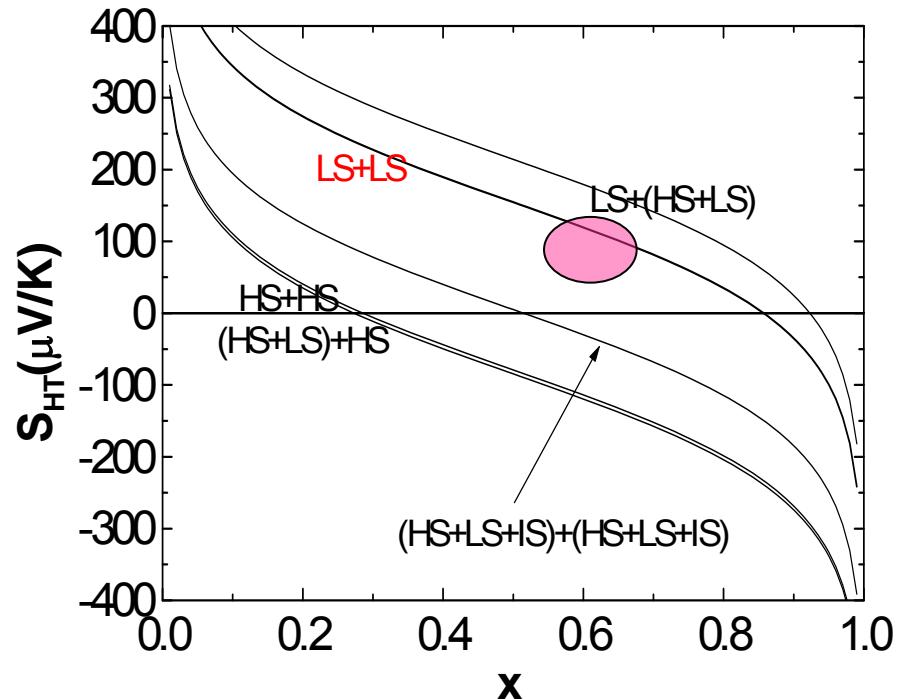
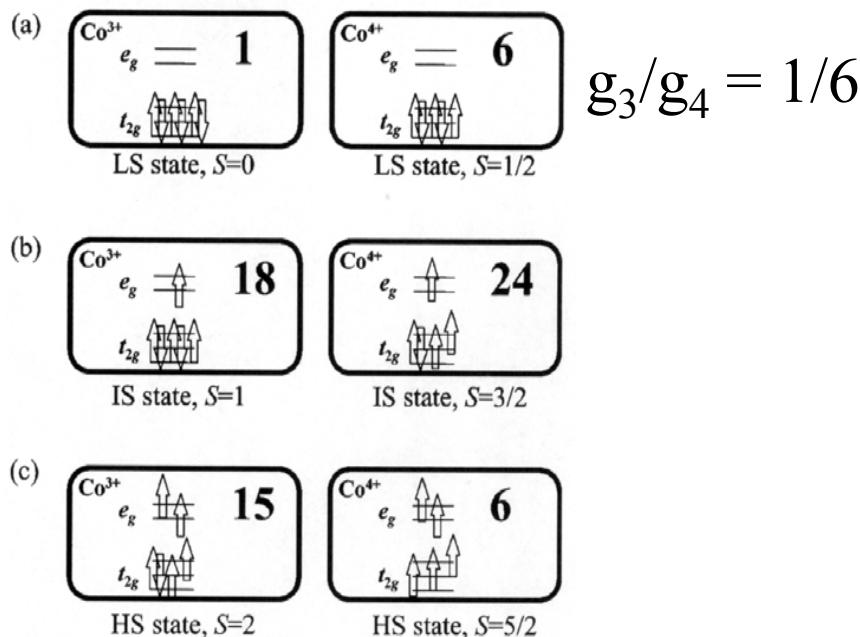


Dégénérescence de spin et d'orbitale Co³⁺ (3d⁶)/Co⁴⁺ (3d⁵)

J. P. Doumerc JSSC 109, 419 (1994)

W. Koshibae et al., Phys. Rev. B 62, 6869 (2000)

$$S = -\frac{k_B}{e} \ln\left(\frac{g_3}{g_4} \frac{x}{1-x}\right)$$



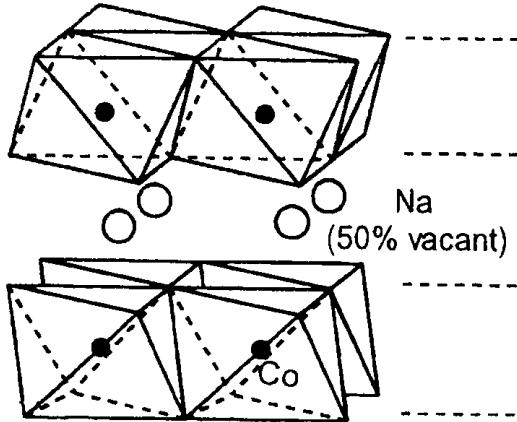
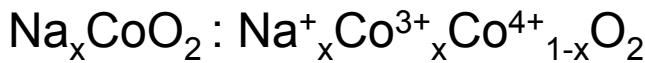
x : Co⁴⁺ concentration

Les oxydes de cobalt à structure lamellaire désaccordée

NaCo₂O₄

‘ Phonon Glass / Electron crystal ’

I. Terasaki et al., Phys. Rev. B 56, R12685 (1997)



Plans type CdI₂

A 300K

Métallicité (cristaux) $\rho \sim 0.2 \text{ m}\Omega \text{ cm}$

Grand S $S \sim +80 \mu\text{V/K}$

Faible κ (polycristaux) $\kappa \sim 2 \text{ Wm}^{-1}\text{K}^{-1}$

(cristaux) $\kappa \sim 5 \text{ Wm}^{-1}\text{K}^{-1}$

Facteur de puissance $P = S^2 / \rho$ at 300K

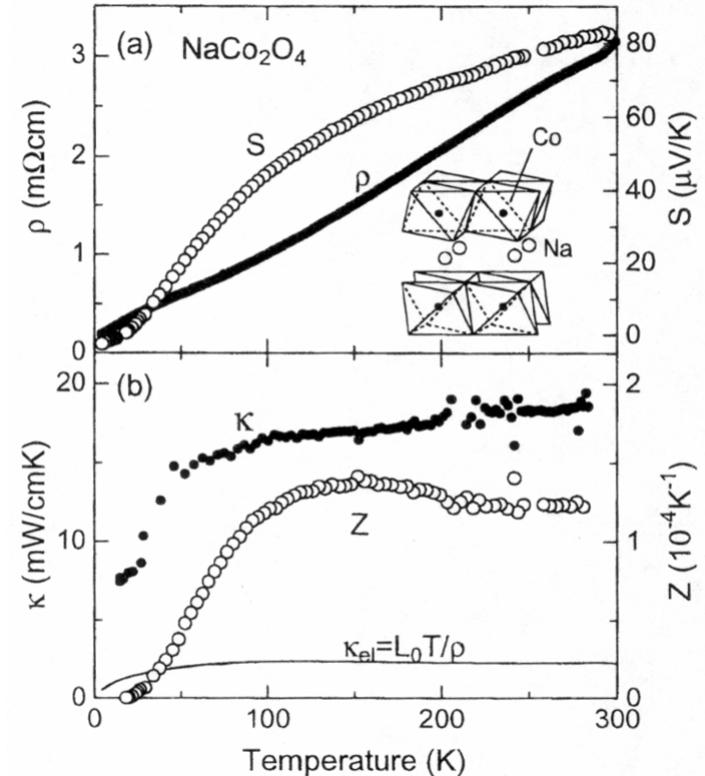
NaCo₂O₄

$P = 50 \cdot 10^{-4} \text{ WK}^{-2}\text{m}^{-1}$

Bi₂Te₃

$P = 40 \cdot 10^{-4} \text{ WK}^{-2}\text{m}^{-1}$

Mesures sur polycristaux



Famille des bronzes de cobalt

Na_xCoO_2

C. Fouassier et al., JSSC6, 532 (1973)

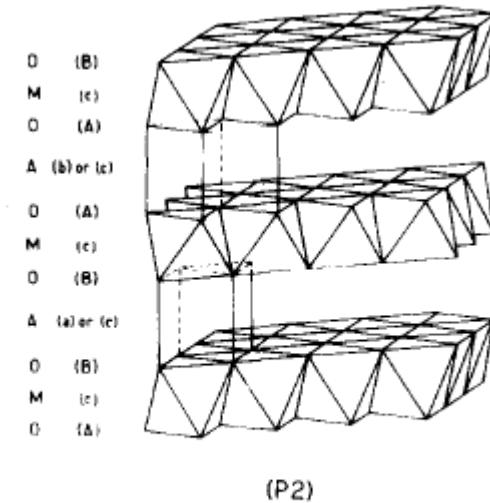
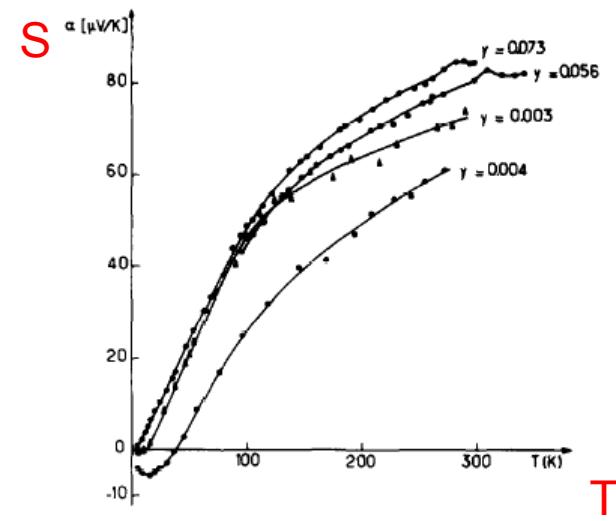
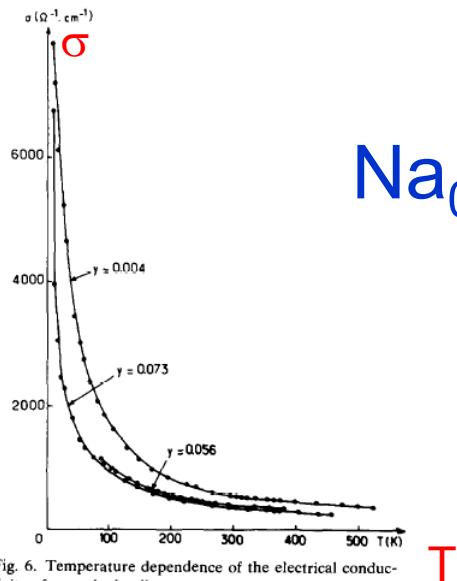


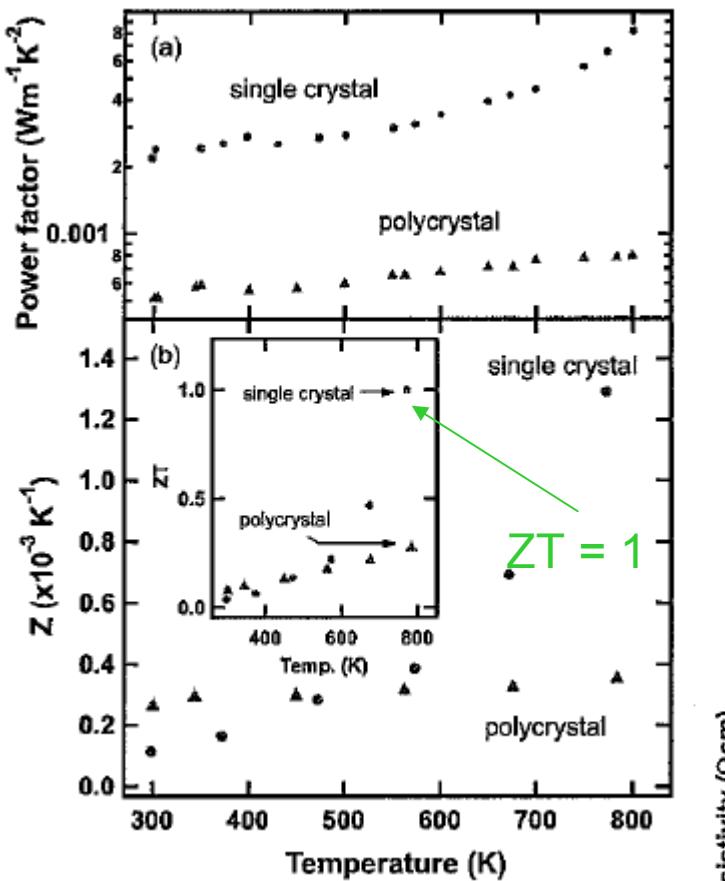
Fig. 1. Layer structure of $\text{Na}_{0.70}\text{CoO}_{2-y}$



J. Molenda, C. Delmas, P. Dordor, A. Stoklosa,
Solid Stat. Ionics 12, 473 (1989)

Propriétés Haute T de Na_xCoO_2

K. Fujita et al. JJAP40, 4644 (2001)

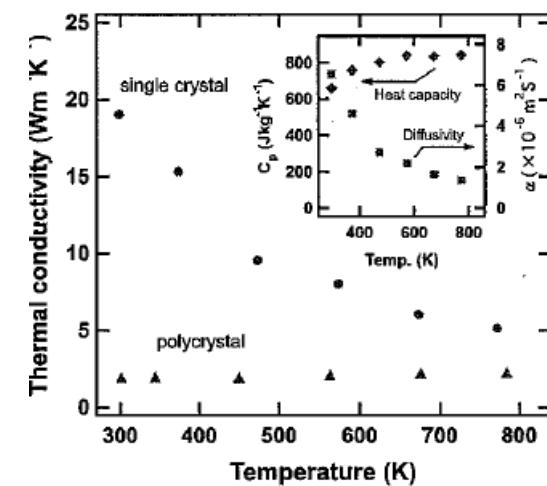
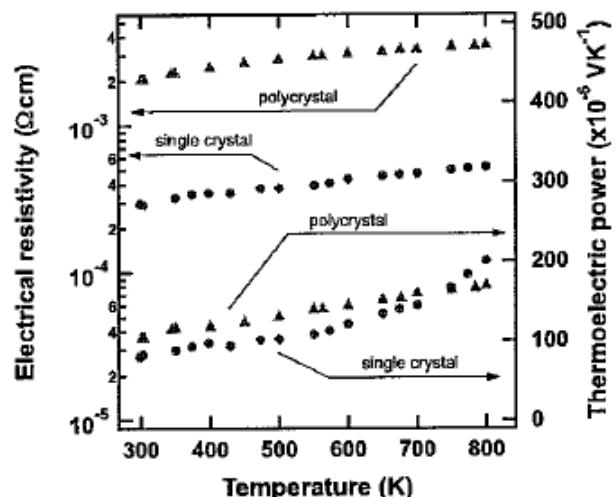


Mesures cristaux / polycristaux

Cristaux : $1.5 \times 1.5 \times 0.03 \text{ mm}^3$

$ZT \sim 1$ pour les cristaux à 800K

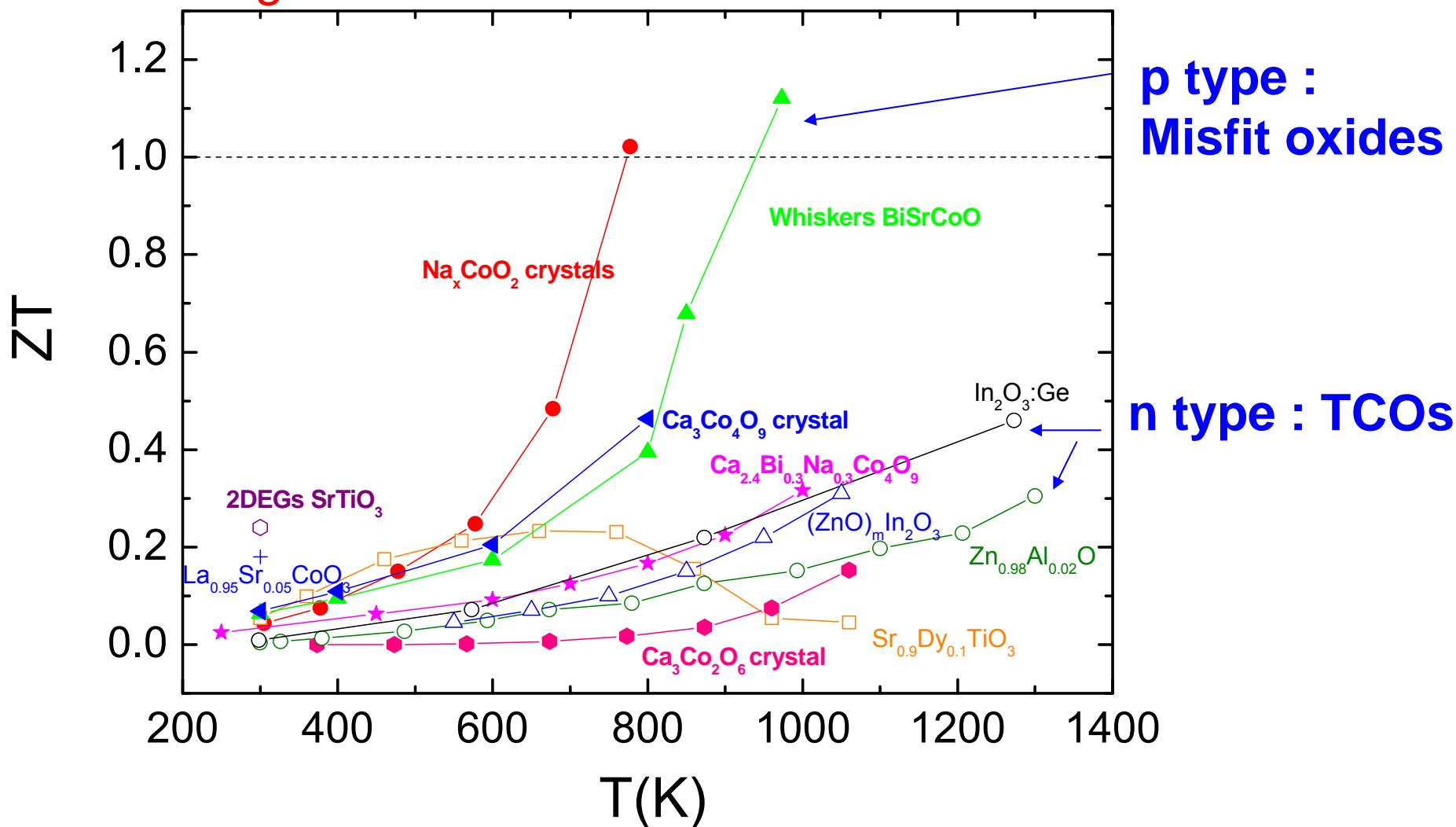
Importance de la texture



Oxides :

ZT of oxides

Potentially stable in air,
at high T



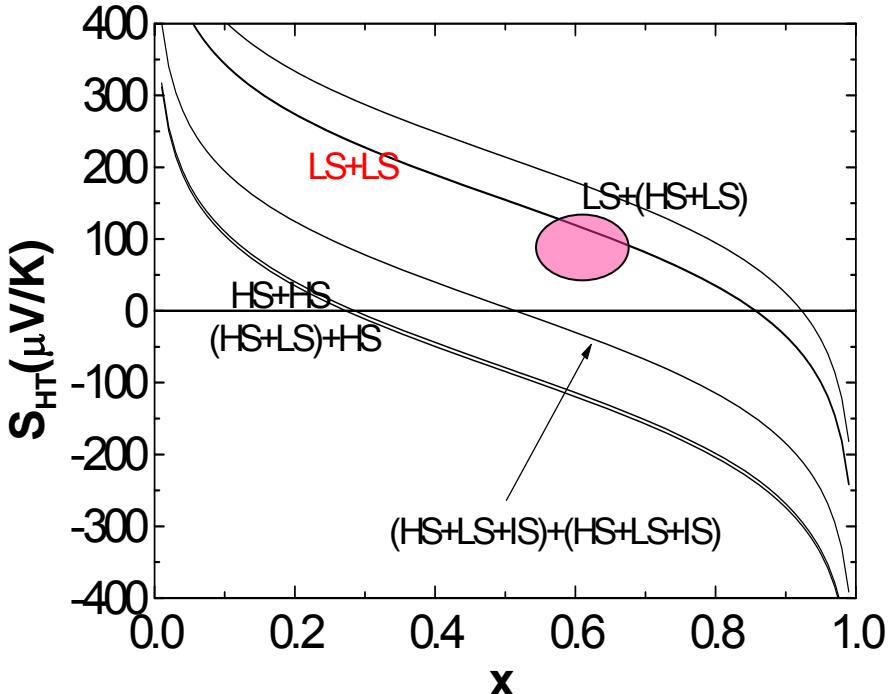
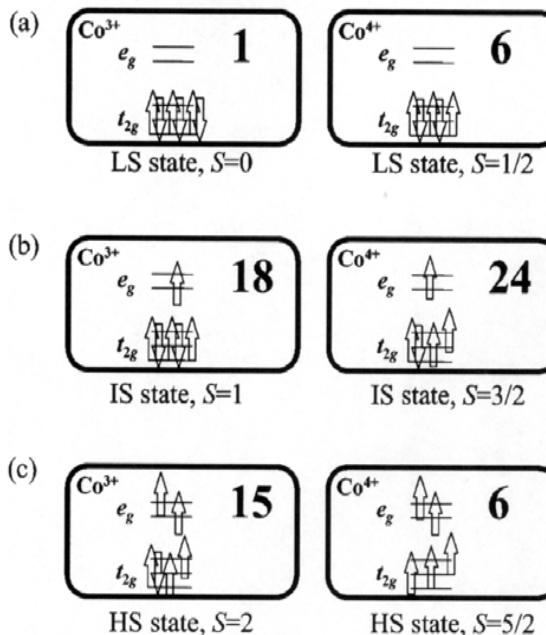
NaxCoO₂ _ Fujita : JJAP 40, 4644 (2001); SrTiO₃ _ Muta : J. Alloys and compounds 350, 292 (2003); Ca_{2.4}Bi_{0.3}Na_{0.3}Co₄O₉ _ Xu : APL80, 3760 (2002); Whiskers BiSrCoO _ Funahashi : APL81, 1459 (2002); Ca₃Co₂O₆ _ Mikami : JAP94, 10 (2003); 2DEGs(SrTiO₃) _ Ohta : Nature Materials 6, 129 (2007); Ca₃Co₄O₉ crystal _ Shikano : APL 82, 1851 (2003); LaSrCoO _ Androulakis : APL84, 1099 (2004); ZnAlO _ Ohtaki : JAP79, 1816 (1996)

Dégénérescence de spin et d'orbitale Co³⁺ (3d⁶)/Co⁴⁺ (3d⁵)

J. P. Doumerc JSSC 109, 419 (1994)

W. Koshibae et al., Phys. Rev. B 62, 6869 (2000)

$$S = -\frac{k_B}{e} \ln\left(\frac{g_3}{g_4} \frac{x}{1-x}\right)$$



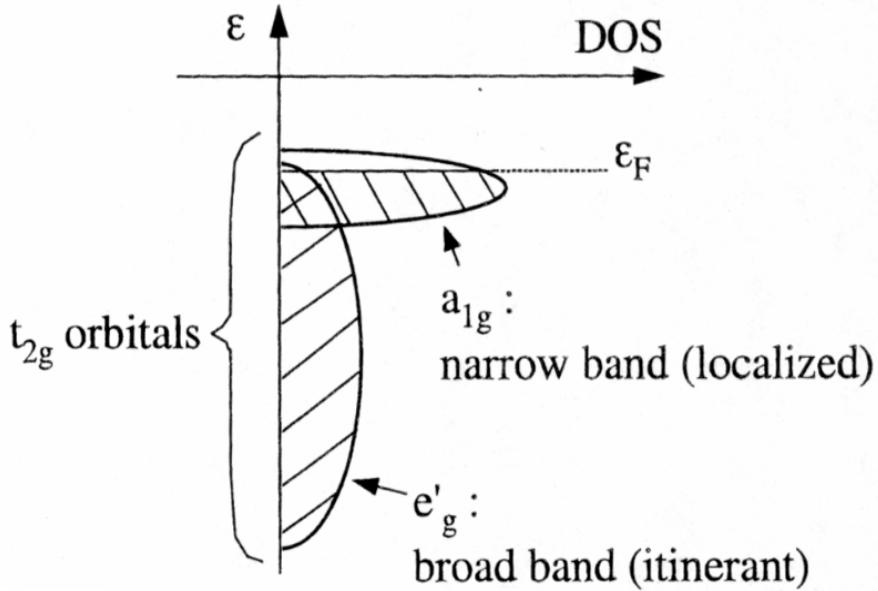
x : Co⁴⁺ concentration

Influence de la structure de bande?

Rhombohedral crystalline field

↳ Lifting of the t_{2g} levels degeneracy

D. J. Singh, Phys. Rev. B 61, 13397 (2000)



Peak in $N(E_F)$

$$\frac{S}{T} = \frac{\pi^2 k^2}{3e} \left(\frac{d \ln(\sigma)}{dE} \right)_{E=E_F}$$

with $\sigma = N(E) < v_F(E)^2 >$

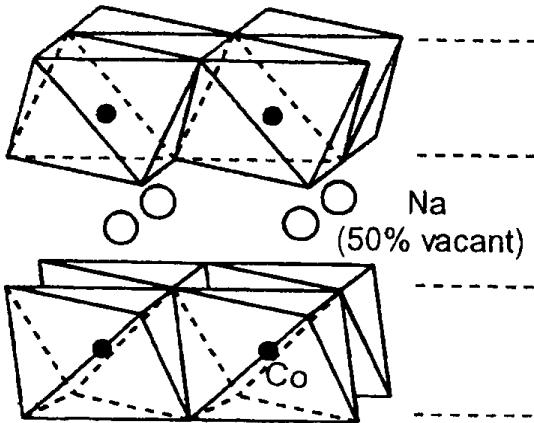
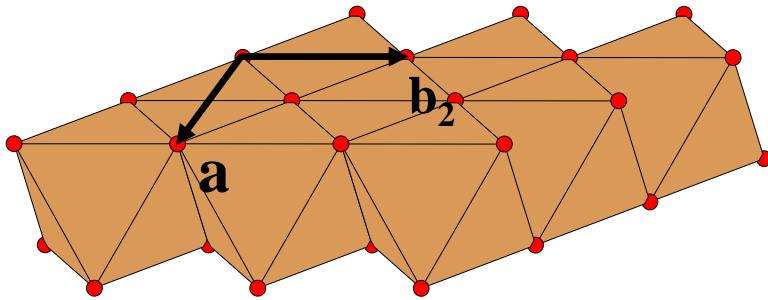
a_{1g} : localized moments / heavy holes

e'_g : mobile carriers / light holes

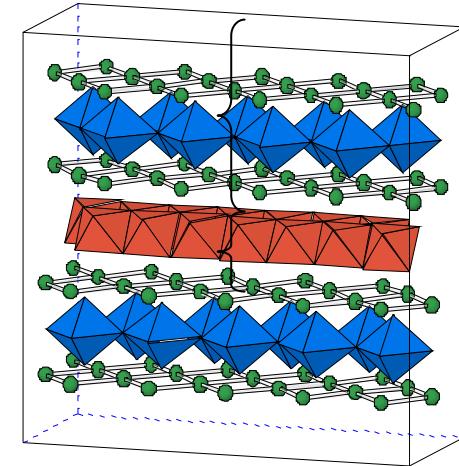
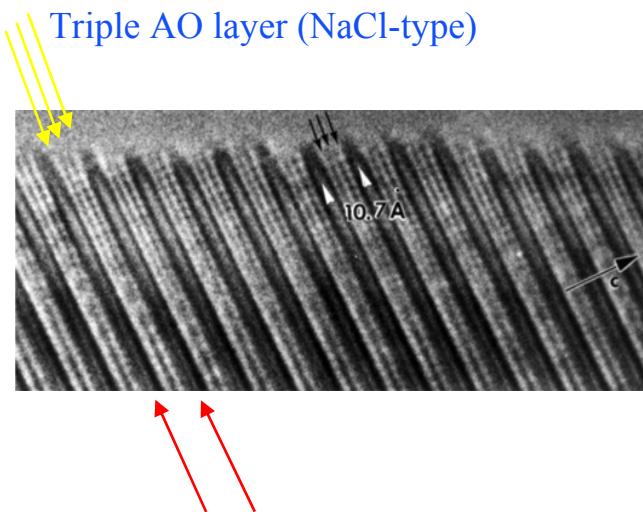
T. Yamamoto et al., Phys. Rev. B 65, 184434 (2002)

↳ $S = +110 \mu V/K$ at 300K
calculated for $NaCo_2O_4$

Oxydes lamellaires à base de plans CoO_2



Na_xCoO_2
 K_xCoO_2 , ...



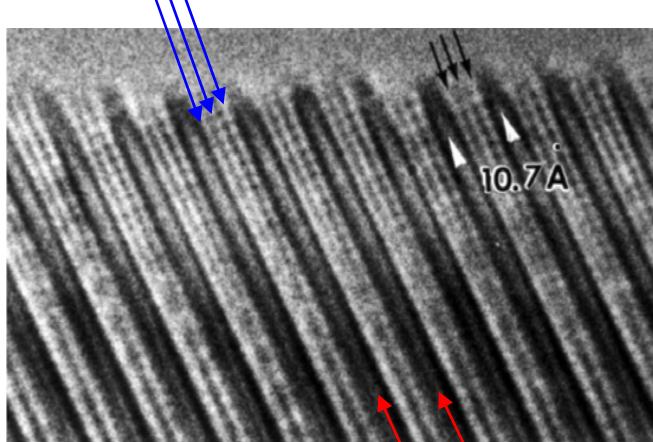
Famille misfit : 2, 3 ou 4 plans séparateurs

Formule de Heikes : influence du dopage?
Influence de la structure de bande : particularité des plans CoO_2 ?
Rôle des plans séparateurs?

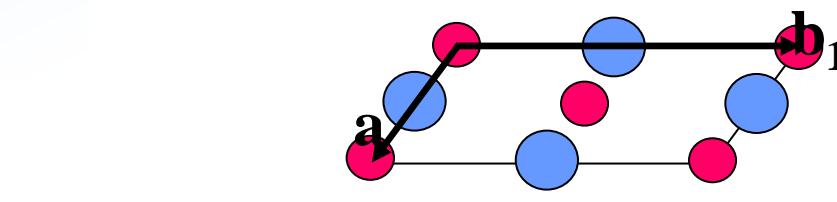
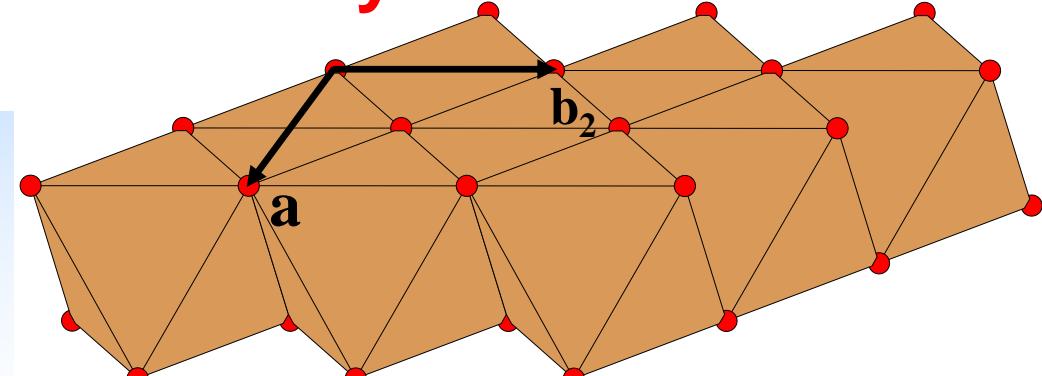
The misfit family

- $n = 4$ $[\text{Bi}_2\text{A}'_2\text{O}_4]^{\text{RS}}[\text{CoO}_2]_{b1/b2}$
 $\text{A}' = \text{Ca}^{2+}, \text{Sr}^{2+} \text{ or } \text{Ba}^{2+}$
- $n = 3$ $[\text{A}'_2\text{CoO}_3]^{\text{RS}}[\text{CoO}_2]_{b1/b2}$
 $\text{A}' = \text{Ca}^{2+} \text{ or } \text{Sr}^{2+}$
- $n = 2$ $[\text{Sr}_2\text{O}_2]^{\text{RS}}[\text{CoO}_2]_{b1/b2}$
 $[\text{Ca}_2(\text{OH})_2]^{\text{RS}}[\text{CoO}_2]_{b1/b2}$

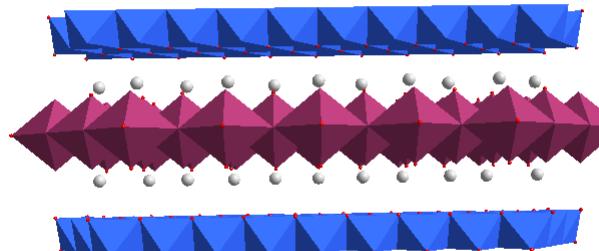
NaCl-like triple layer (RS)



CoO_2 (type CdI_2)



b
a
c



$$\begin{aligned} a_1 &= a_2 \\ c_1 &= c_2 \\ \beta_1 &= \beta_2 \end{aligned}$$

$$b_1 \neq b_2$$

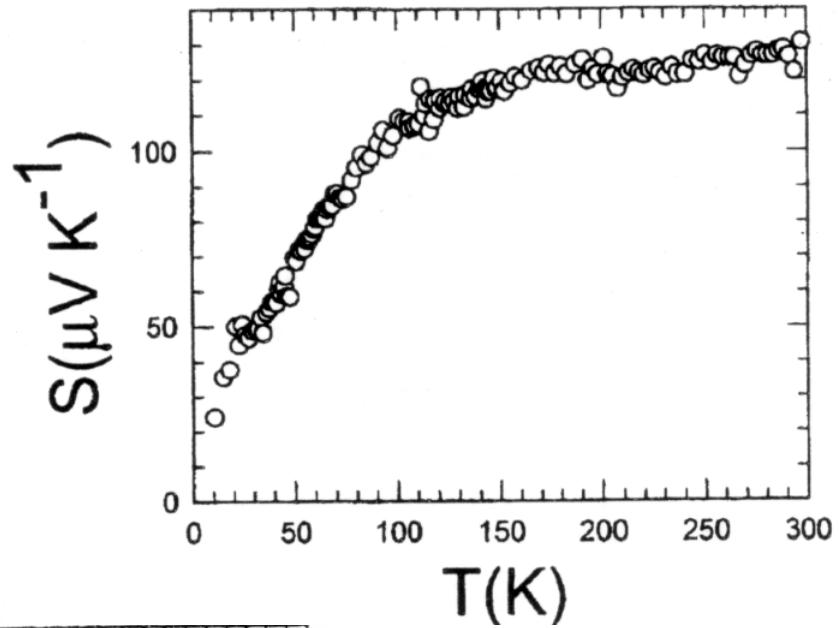
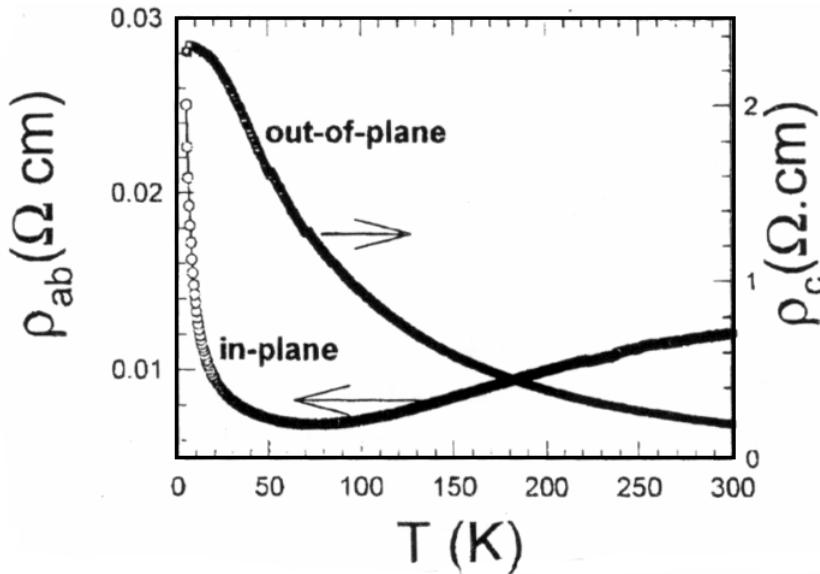
Leligny et col., C. R. Acad. Sci. Paris, t. 2, Série II c, 409 (1999)

Boullay et col., Chem. Mater. 8, 1482 (1996)

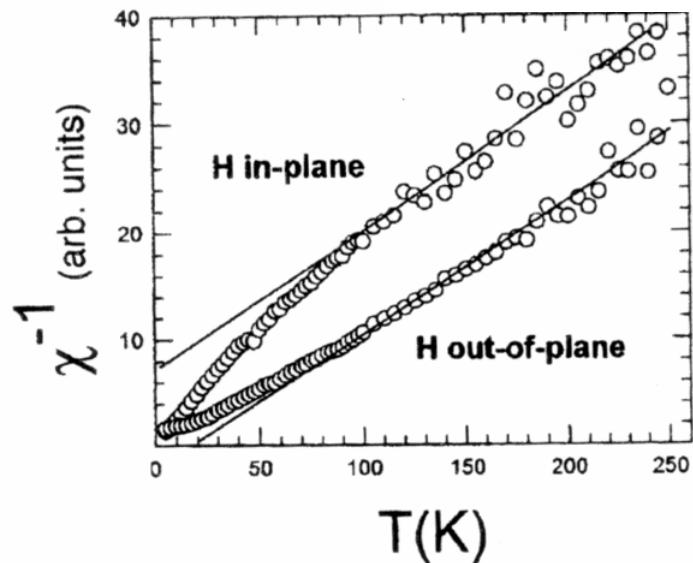
Masset et col., Phys. Rev. B 62, 166 (2000)
Yamauchi et col., Chem. Mater. 18, 155 (2005)

$\text{Ca}_3\text{Co}_4\text{O}_9$ single crystals

A. C. Masset et al., Phys. Rev. B 62, 166 (2000)

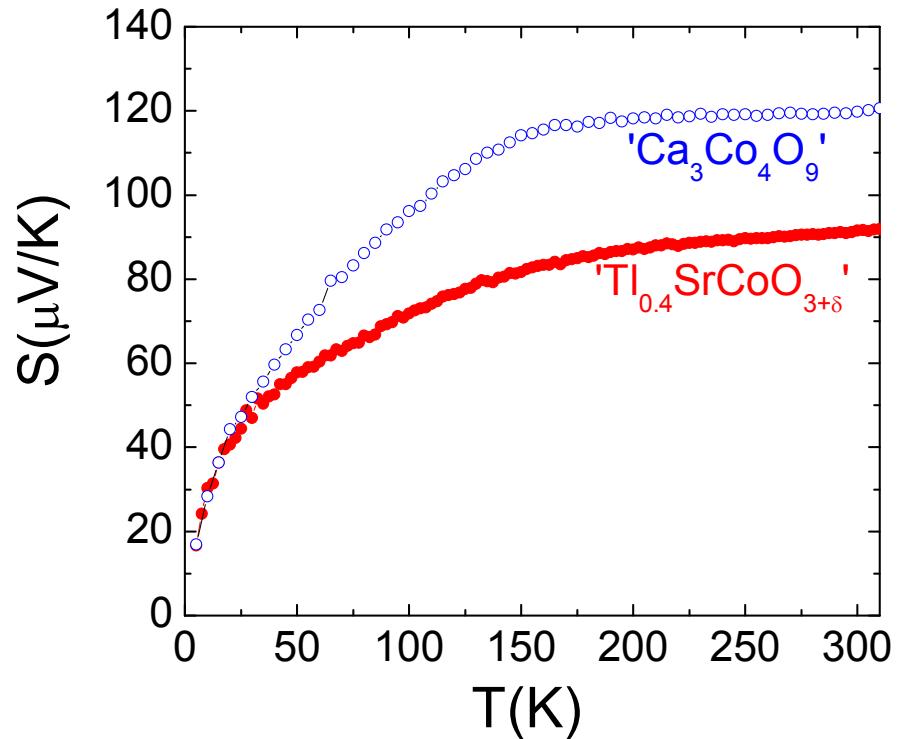
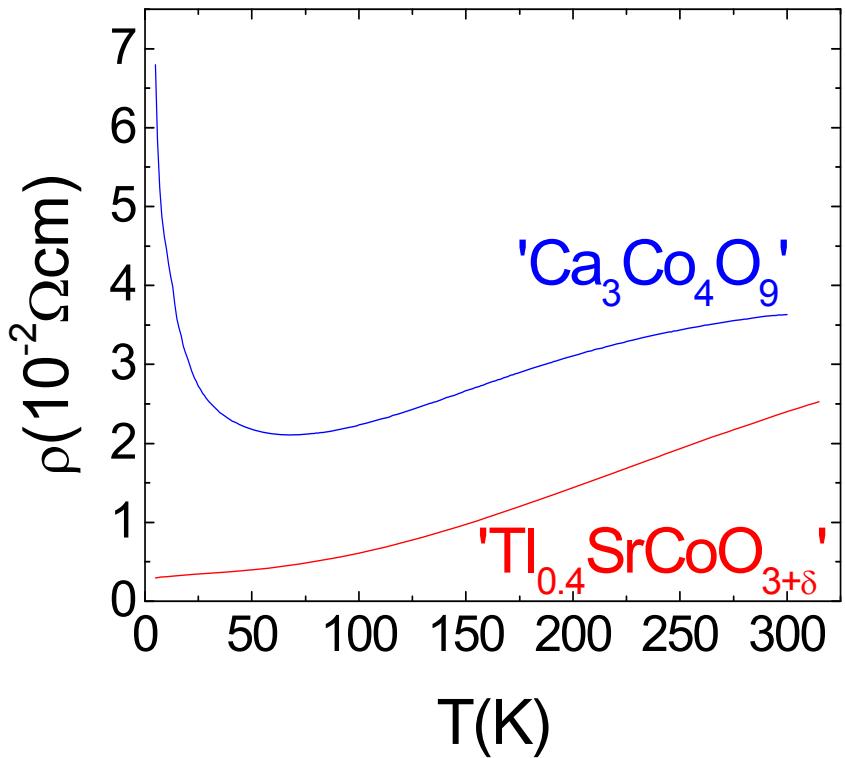


Magnetic
measurements :
 $\text{Co}^{3+} \text{ LS} / \text{Co}^{4+} \text{ LS}$



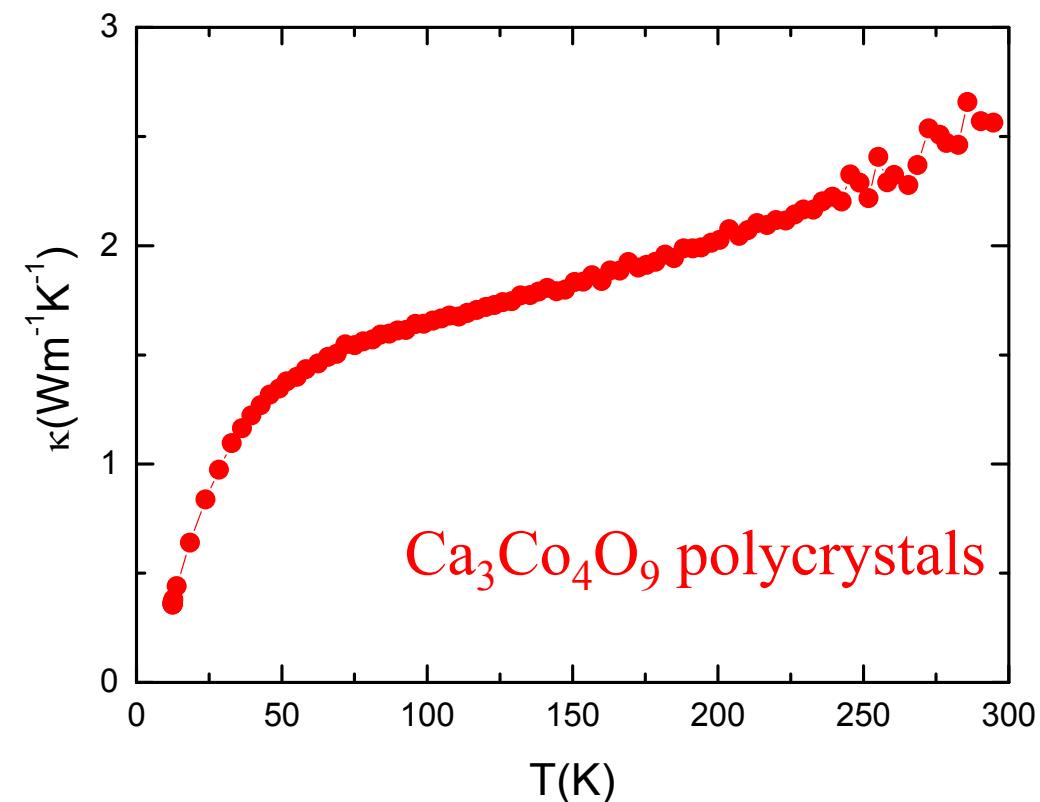
Metallicity
+
Large S

Two different behaviours at low T



Different resistivities but same $S(T)$
Only a shift of S

Thermal conductivity



Wiedemann-Franz law :

$$\frac{\kappa_{\text{el}}}{\sigma T} = \frac{3}{2} \left(\frac{k_B}{e} \right)^2$$

$\kappa_{\text{el}} \sim 0.03 \text{ Wm}^{-1}\text{K}^{-1}$ at 300K

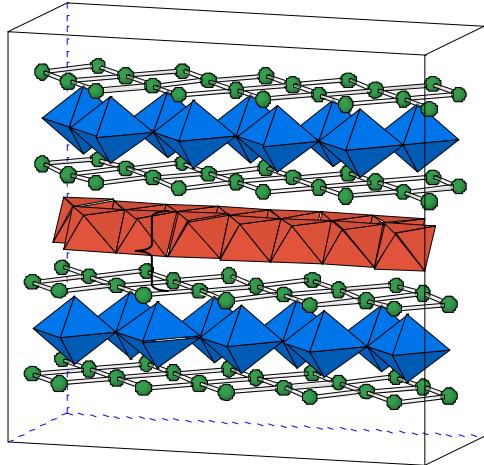
κ mainly from phonons

Influence du dopage dans les misfits



Ca_2CoO_3
NaCl-like

CoO_2
 CdI_2 -like



Electronic neutrality :



2+

3+

2-

v_{Co}

2-

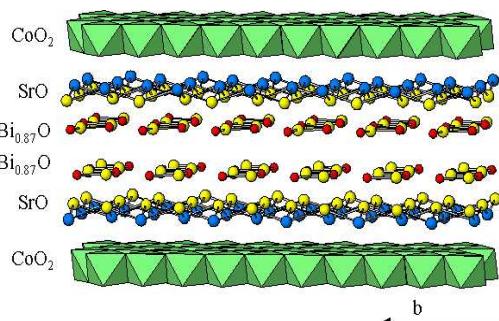
$$\alpha > 0$$

$$v_{\text{Co}} = 4 - \frac{\alpha}{b_1 / b_2}$$

Modification de v_{Co} via α et b_1/b_2

Lien entre v_{Co} et S ?

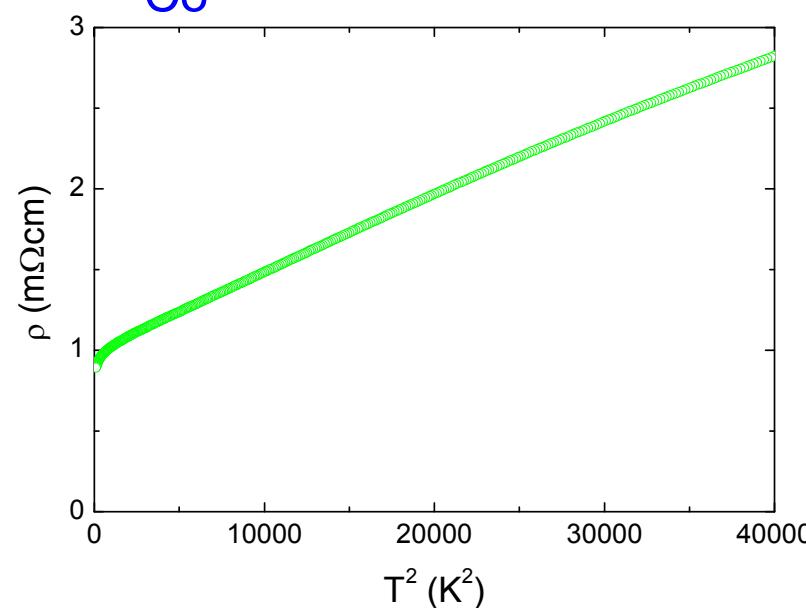
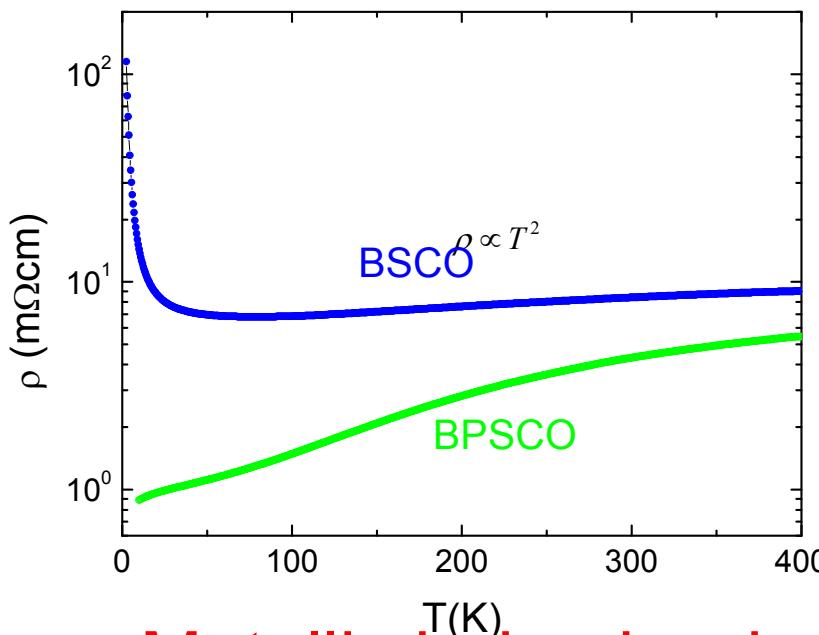
BiSrPbCoO single crystals : modification of α



$$v_{Co} = 4 - \frac{\alpha}{b_1 / b_2}$$



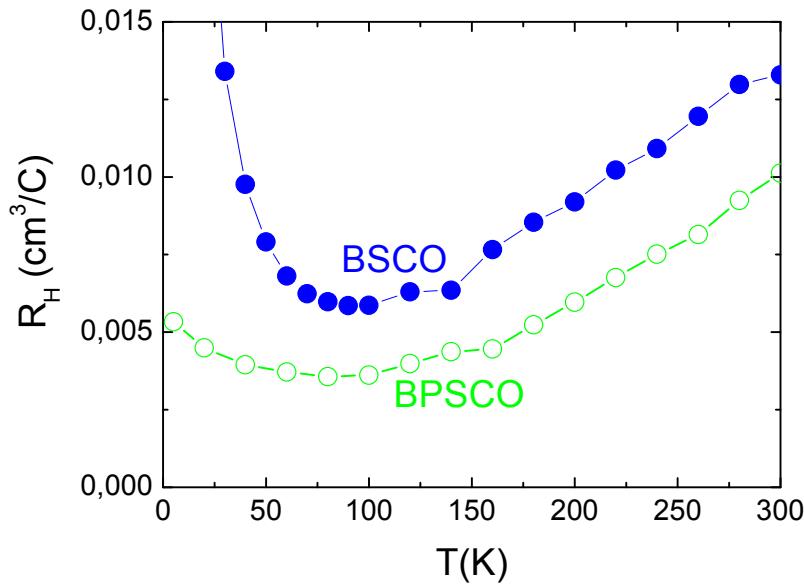
Substitution of Bi³⁺ by Pb²⁺ : decrease of α
Increase of v_{Co}



Metallic behavior down to 5K with $\rho = AT^2$

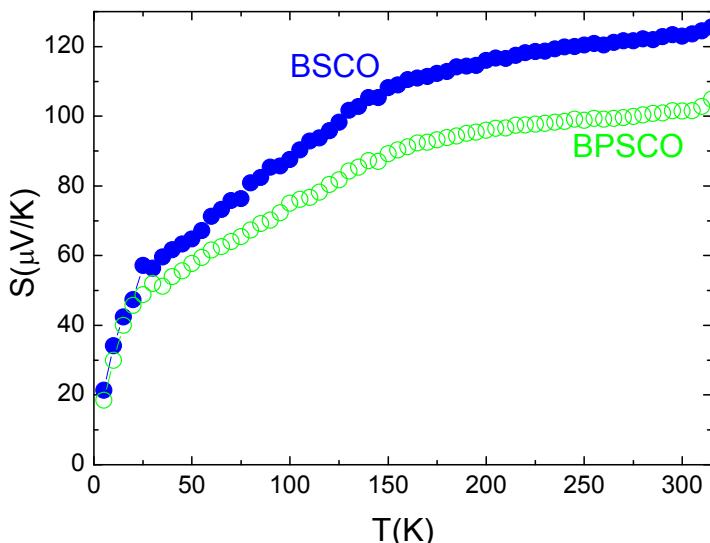
Characteristic of electronic correlations

BiSrPbCoO single crystals : modification of α



At 100K
 $1.73 \times 10^{21} \text{ cm}^{-3}$ for BPSCO
 $1.06 \times 10^{21} \text{ cm}^{-3}$ for BSCO

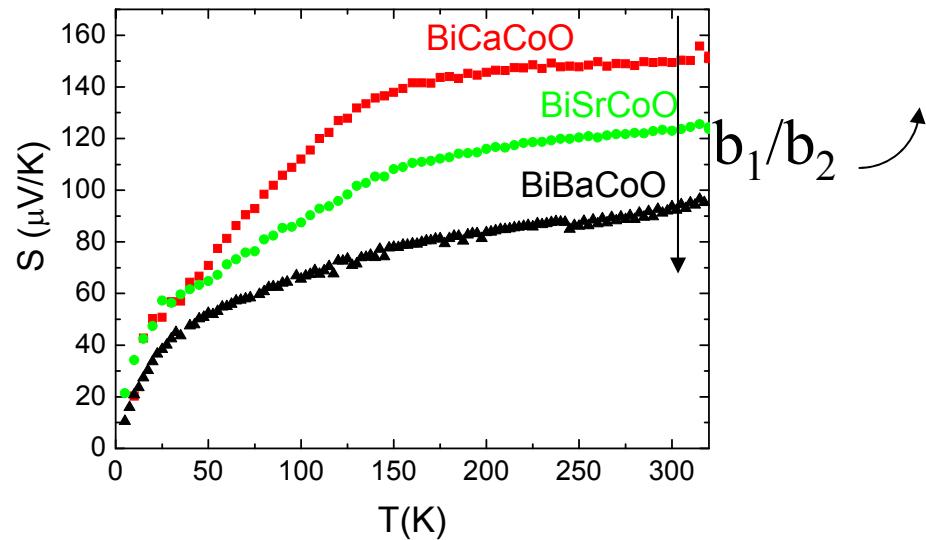
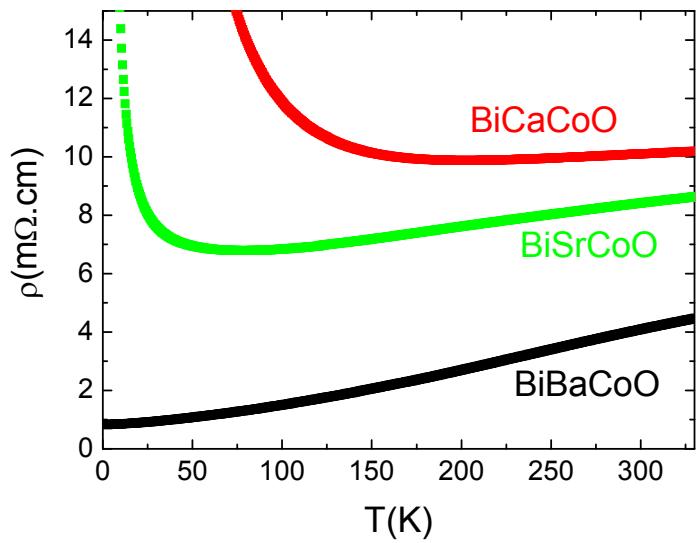
Increase of v_{Co}
3.109 for BSCO
3.178 for BPSCO



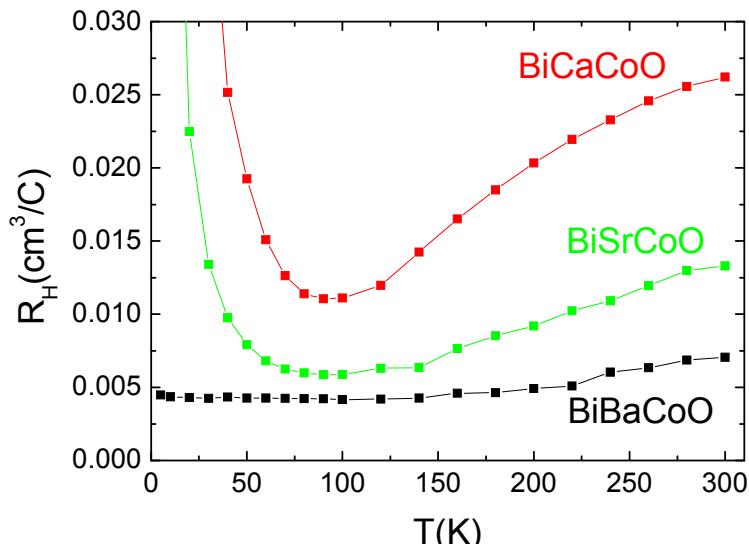
Increase of ' Co^{4+} ' associated to a decrease of S

From the generalized Heikes formula,
increase of v_{Co}
3.59 for BSCO and 3.65 for BPSCO

BiCaCoO/ BiSrCoO/ BiBaCoO single crystals



S not affected by the strong modification of ρ

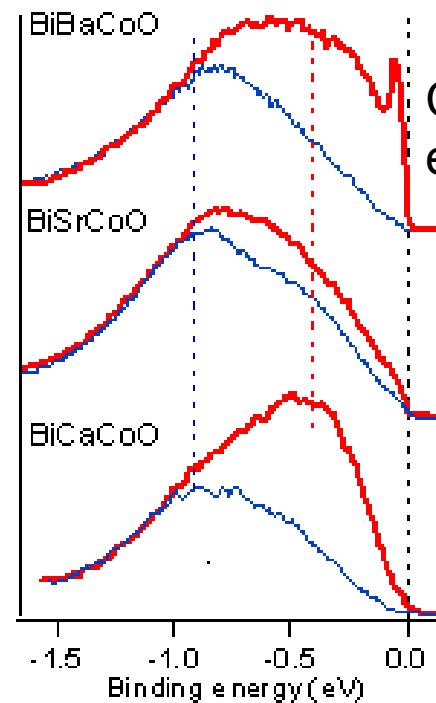
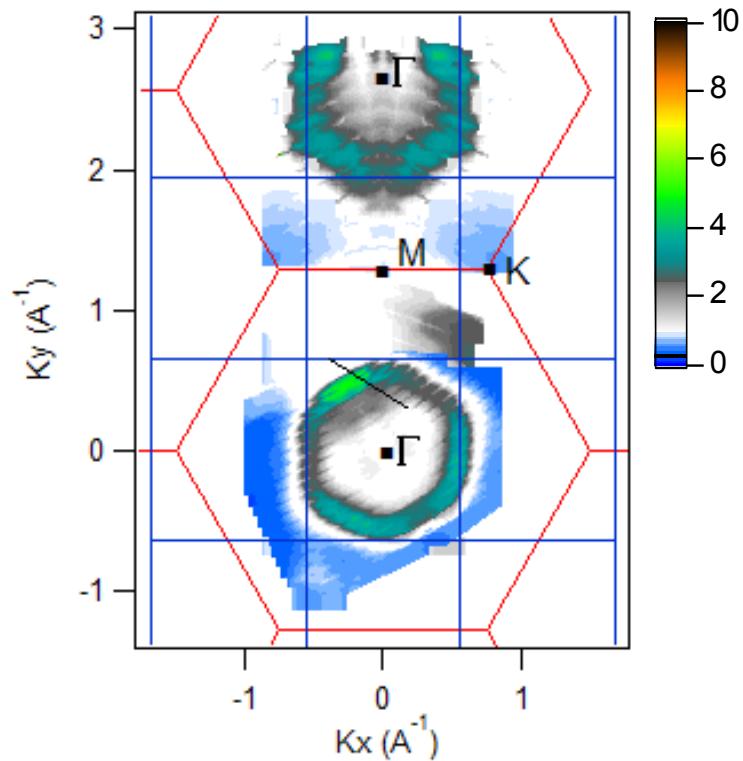


If b_1/b_2 ↑, carrier concentration ↑

$$v_{Co} = 4 - \frac{\alpha}{b_1 / b_2}$$

↳ S at 300K depends on doping
 $V_{Co} = 3.05 - 3.15$ (Hall effect)?

Carrier concentration changes with misfit ratio b_1/b_2



Collaboration with V. Brouet et al., LPS Orsay

Reliable data for v_{Co} are obtained for BiBaCoO

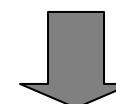
single hole-like fermi surface (a_{1g} character)

$$k_F = 0.57 \pm 0.05 \text{ \AA}^{-1} \text{ for BiBaCoO}$$

- similar to k_F of Na_xCoO_2 ($x=0.7$)
- $\text{Co}^{3.3+}$ for BiBaCoO

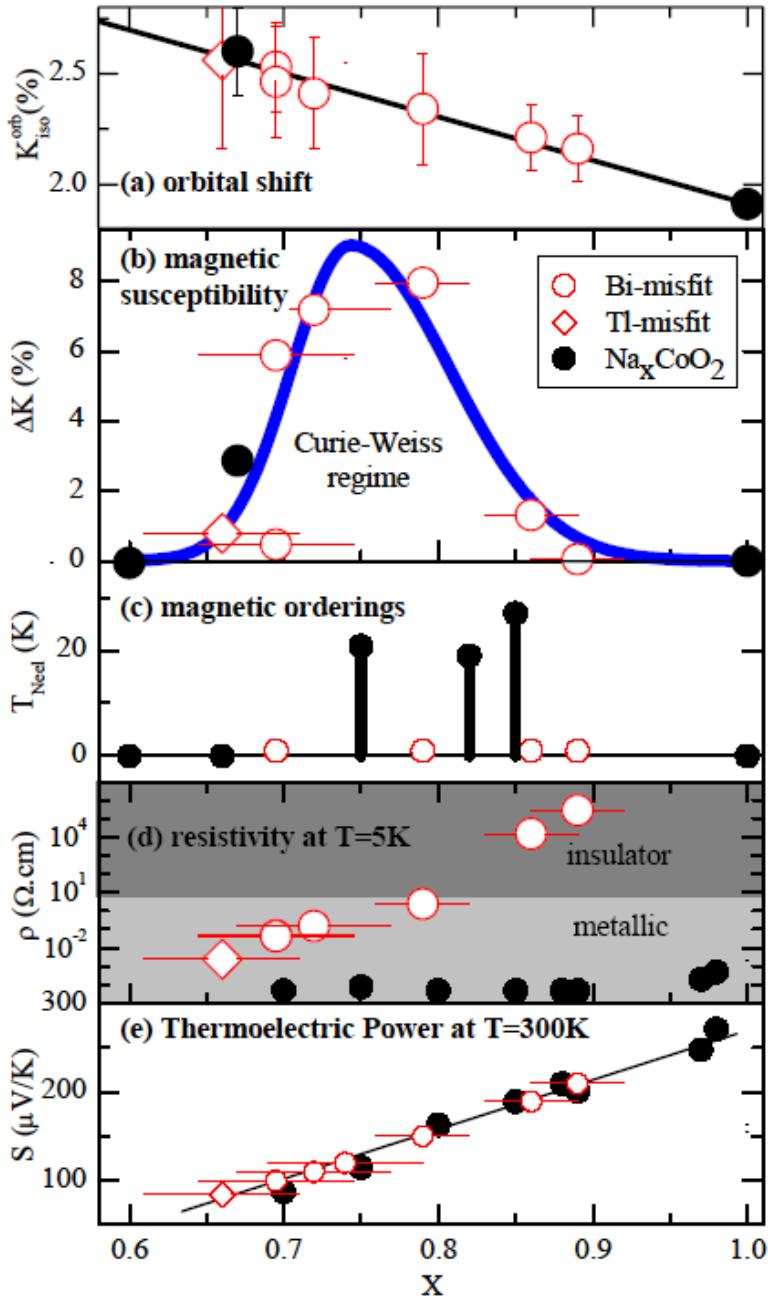
V. Brouet et al., PRB76, 100403 (2007)

$$v_{Co} = 4 - \frac{\alpha}{b_1/b_2} (\alpha = \text{const})$$



$\text{Co}^{3.2+}$ for BiSrCoO
 $\text{Co}^{3.1+}$ for BiCaCoO

Comparison with Na_xCoO_2



NMR experiments

Comparison of Seebeck coefficients of misfits and Na_xCoO_2

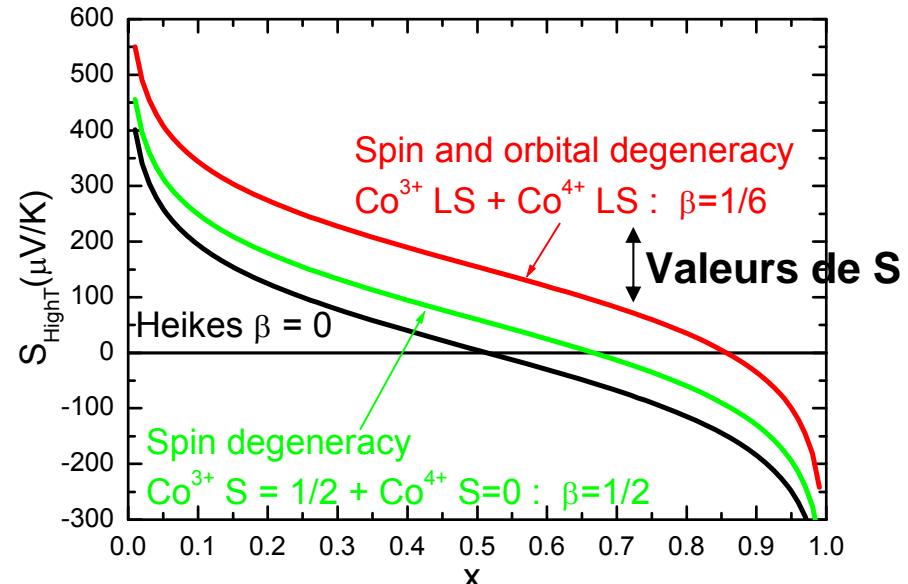
Confirms the Co^{4+} content determined through ARPES measurements

$$\begin{array}{l} \text{Bi/Ca/Co/O : 3.1} \\ \text{Bi/Sr/Co/O : 3.2} \\ \text{Bi/Ba/Co/O : 3.3} \end{array}$$

$$v_{\text{Co}} = 4 - \frac{\alpha}{b_1 / b_2}$$

Heikes formula

$$S = -\frac{k_B}{e} \ln\left(\frac{g_3}{g_4} \frac{x}{1-x}\right)$$



Co valency in BiCaCoO/ BiSrCoO / BiBaCoO

| Heikes $g_3/g_4 = 1/6$ S at 300K | Hall effect | ARPES BiBaCoO | NMR |
|--|-----------------------------------|--|--|
| 3.5 -3.7 | 3.05 -3.15 W. Kobayashi et al. | 3.3 V. Brouet et al., PRB76, 100403 (2007) | 3.1 -3.3 J. Bobroff et al., PRB76, 100407 (2007) |

$g_3 / g_4 = 1/2$ instead of 1/6?

Confirms the results in BiCaCoO : $v_{Co} = 3.24$

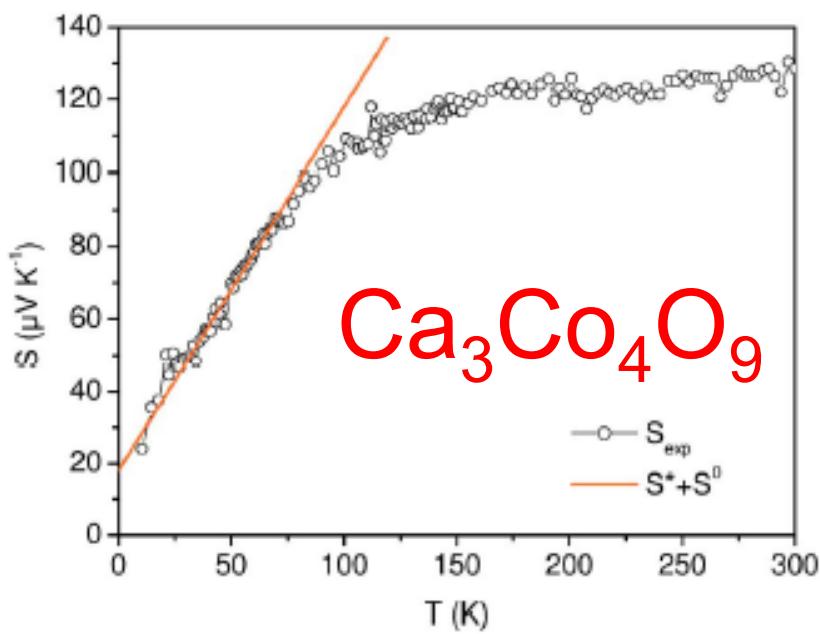
M. Pollet et al., JAP101, 083708 (2007)

Importance des corrélations électroniques

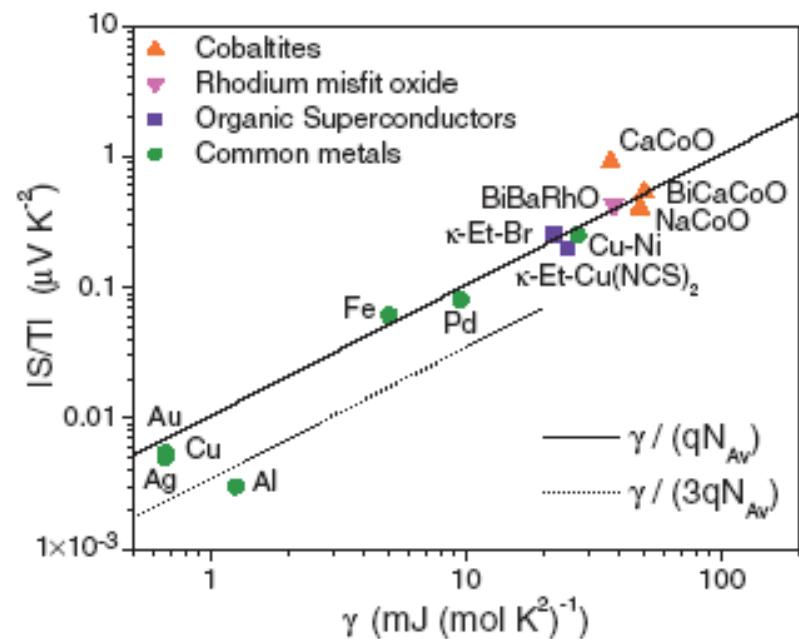
Pour $T \rightarrow 0$

$$q = \frac{S}{T} \frac{N_{Av} e}{\gamma} = \text{cste}$$

$$S \sim \gamma T$$



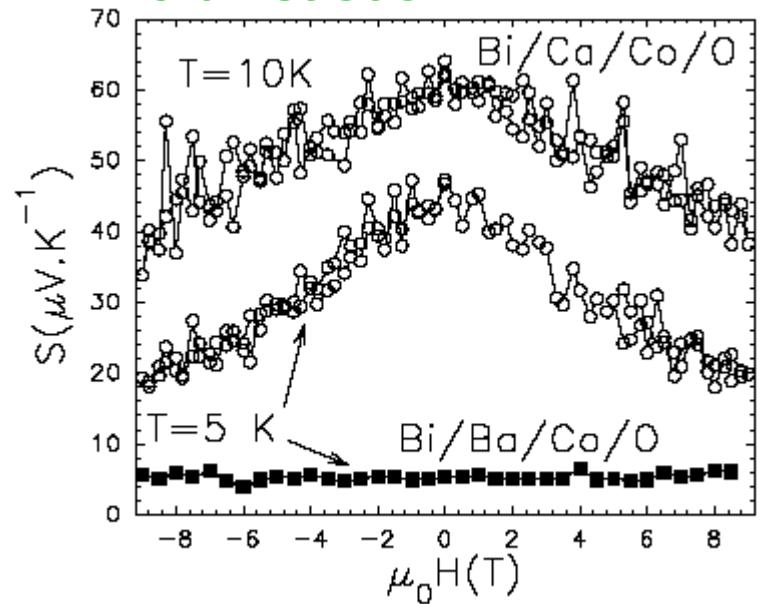
P. Limelette, PRB71, 233108 (2005)



P. Limelette, PRL97, 046601 (2006)

Spin entropy at low T

Misfit BiCaCoO

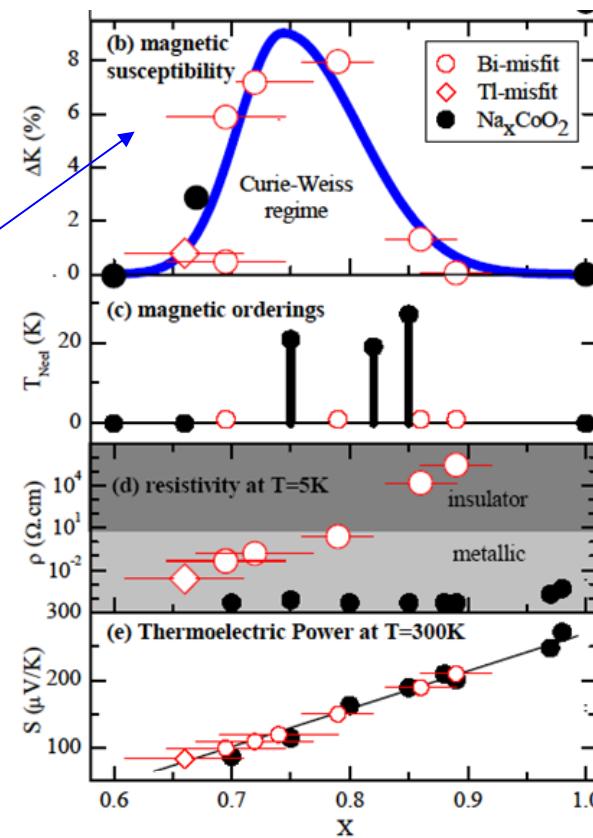


P. Limelette et al., PRL97, 046601 (2006)

Decrease of S in field at low T
Due to the alignment of paramagnetic spins

A. Maignan et al.,
JPCM15, 2711
(2003)

Peak of susceptibility



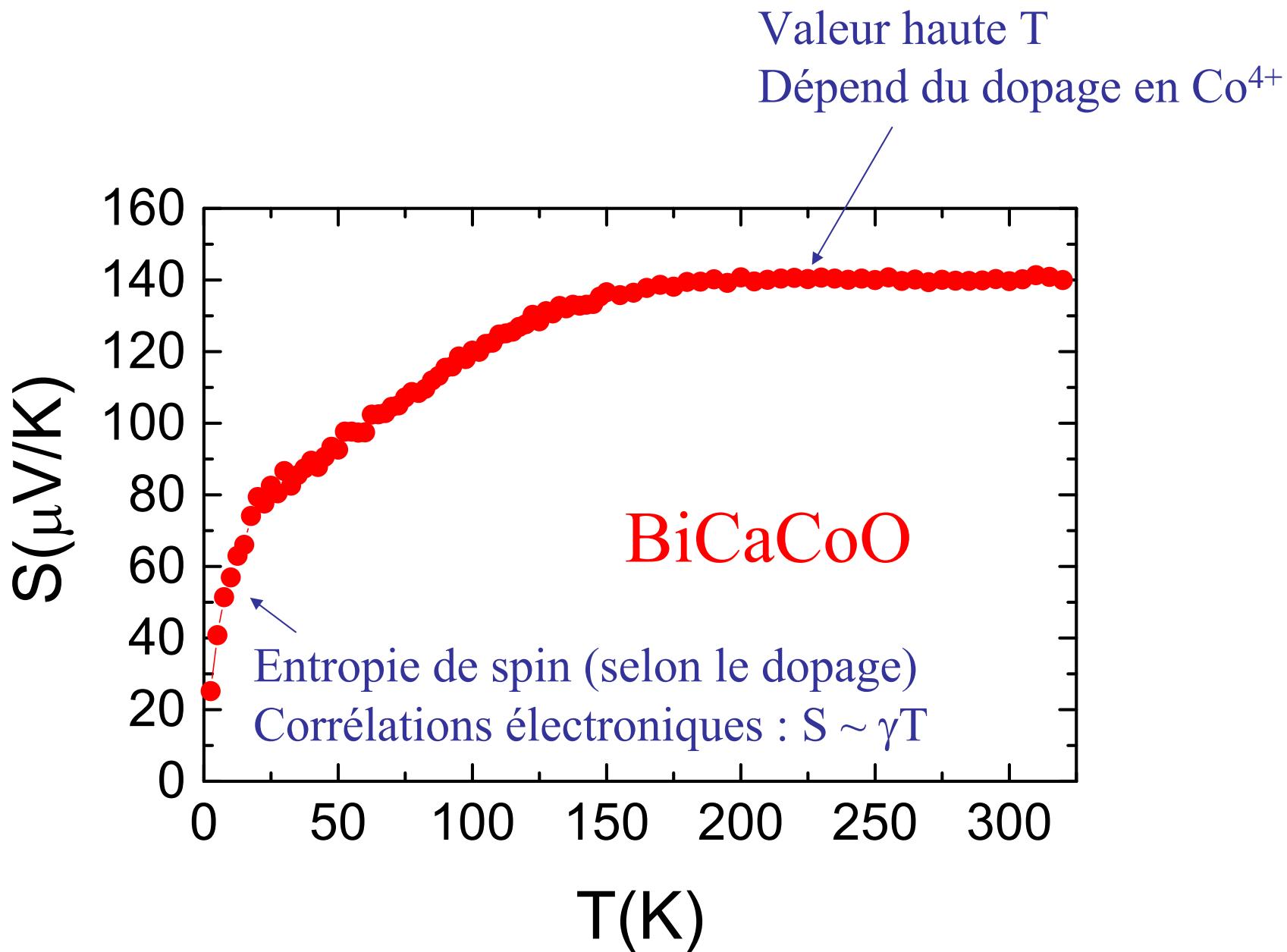
Scaling law for $S(H)$: paramagnetic spins $S=1/2$
Brillouin function

$$S(x)/S(0) = (\ln[2 \cosh(x)] - x \tanh[x]) / \ln(2).$$

$\text{Na}_{0.7}\text{CoO}_2$

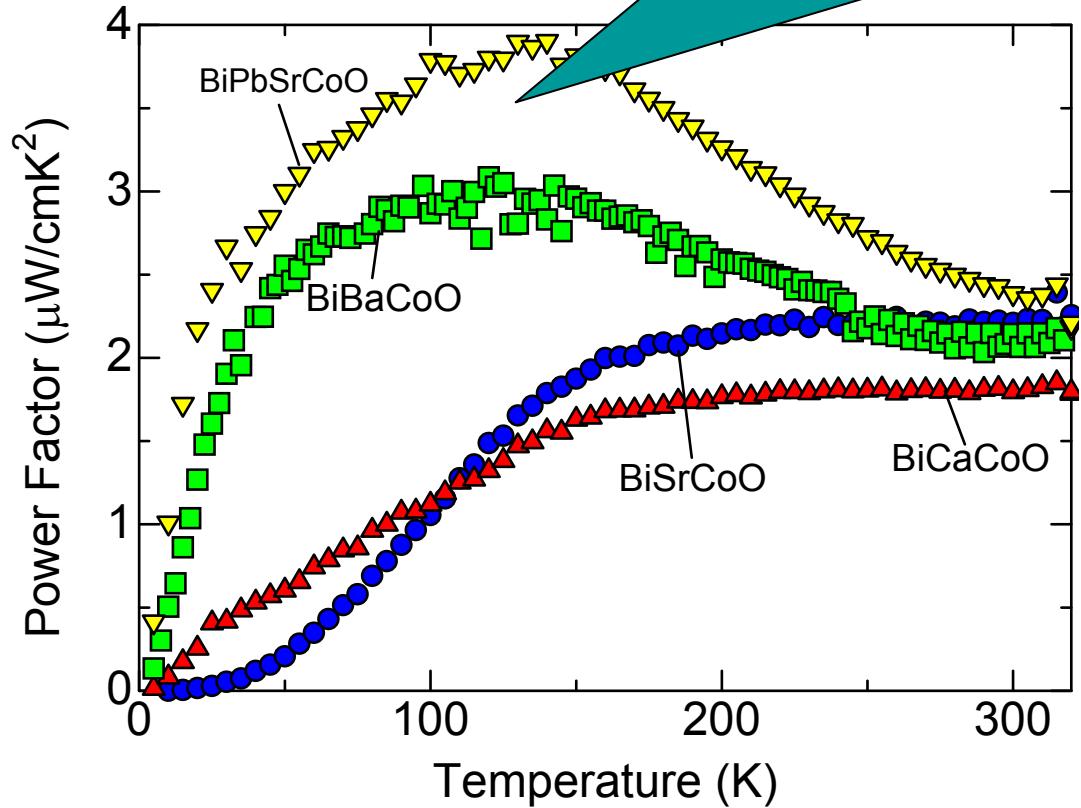
Y. Wang et al., Nature423, 425 (2003)

Pouvoir thermoélectrique des misfits



Power factor P in Bi family

enhancement for BiBaCoO and BiPbSrCoO



P is almost
independent of carrier
concentration

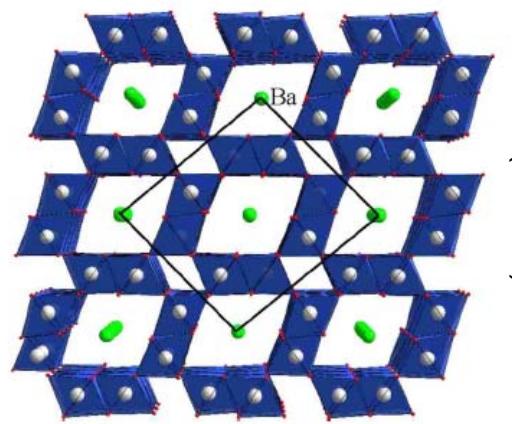
$$2 \cdot 10^{-4} \text{ Wm}^{-1}\text{K}^{-2}$$

What is the origin?

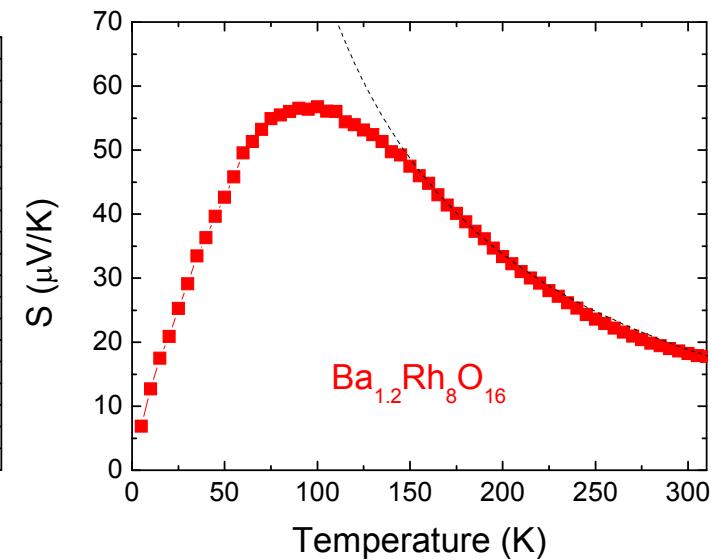
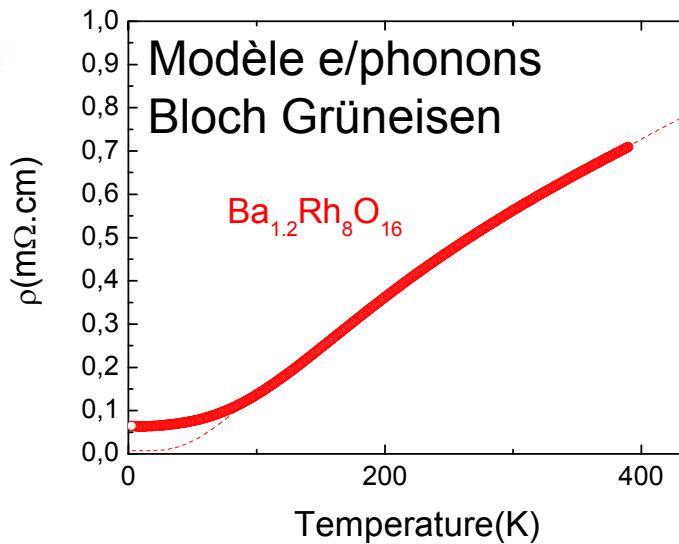
In conventional semiconducting thermoelectric material such as Bi_2Te_3 , n is an important parameter to tune the properties.

How to modify the electronic properties?
Other structures with CdI_2 type layers?

$\text{Ba}_{1.2}\text{Rh}_8\text{O}_{16}$ hollandite



Quasi 1D structure

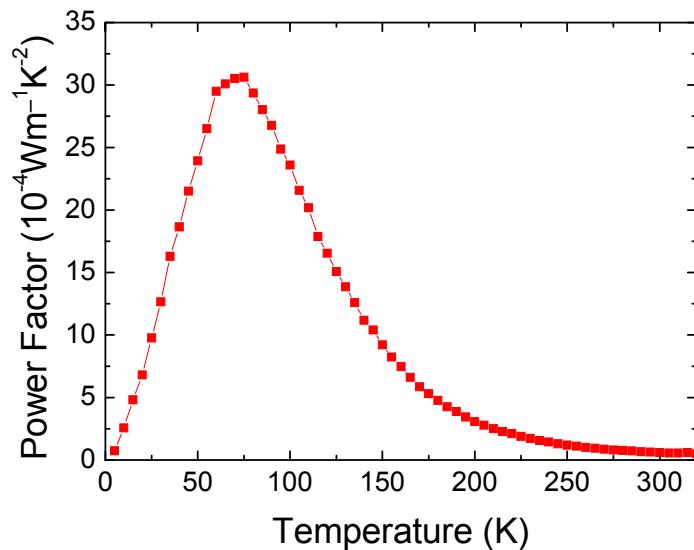


Tunnels made of edge shared octahedra

Needle like single crystals

Hall effect : $1.01 \times 10^{22} \text{ cm}^{-3}$ at 300K

For comparison : $190 \cdot 10^{-4} \text{ Wm}^{-1}\text{K}^{-2}$
for $\text{Na}_{0.88}\text{CoO}_2$ at 75K



Conductivité thermique

Mesures sur monocristaux par la méthode d'Harman

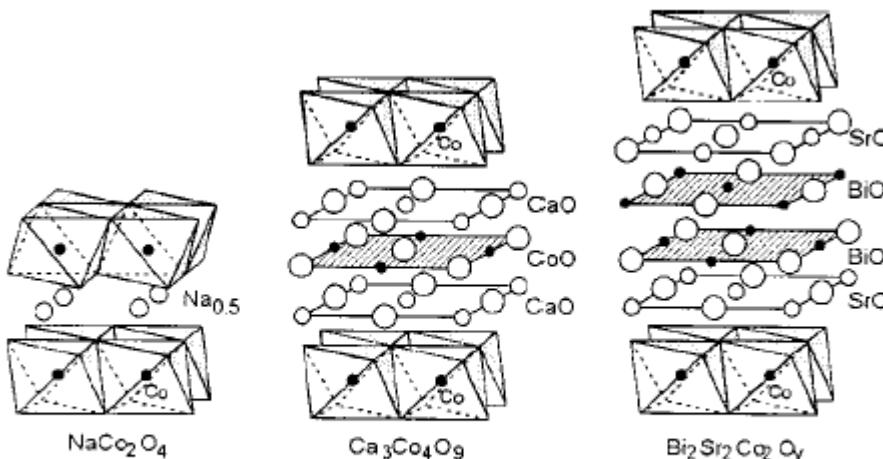
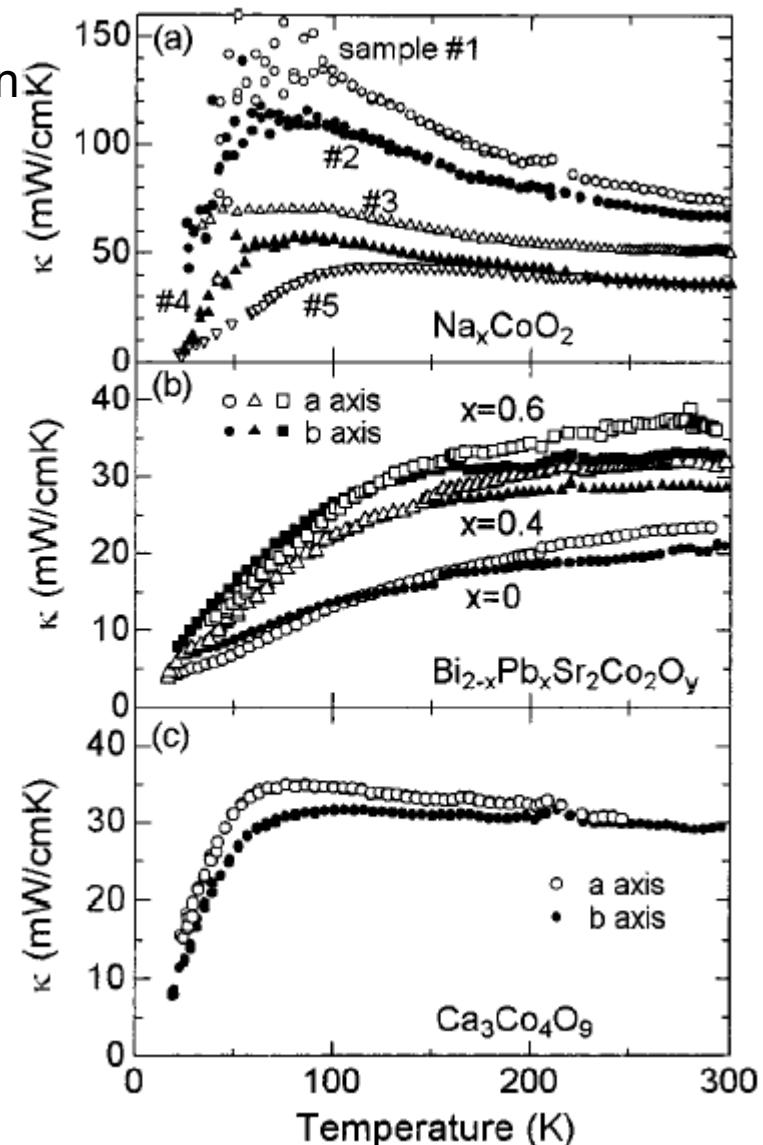


FIG. 1. Crystal structure of the layered cobalt oxides.

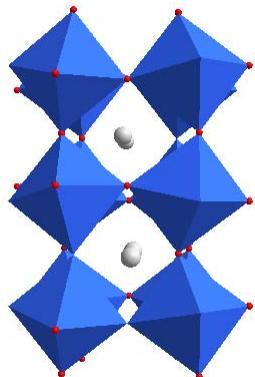
κ légèrement plus faible dans les misfits

Influence de l'incommensurabilité?



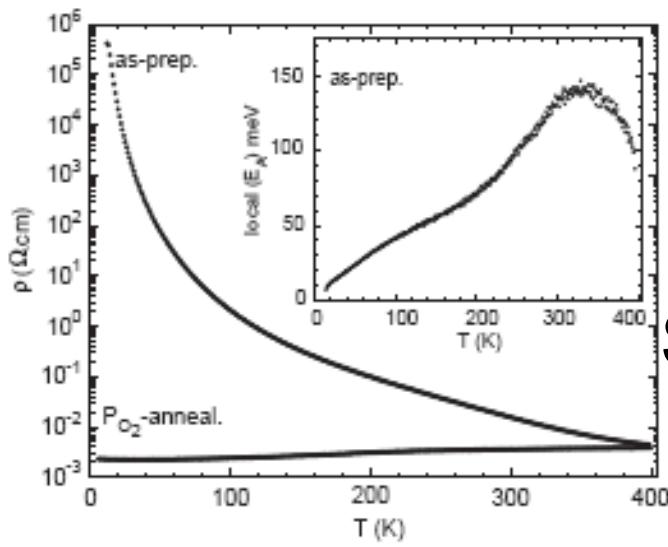
Comportement unique des plans CdI₂ : Comparaison avec d'autres oxydes

b
a
c

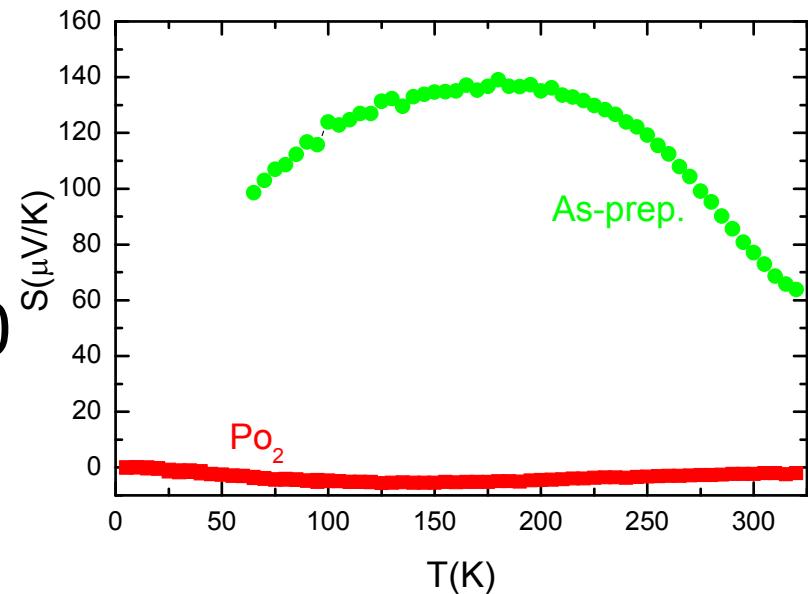


Perovskite $\text{Sr}_{2/3}\text{Y}_{1/3}\text{CoO}_{8/3+\delta}$

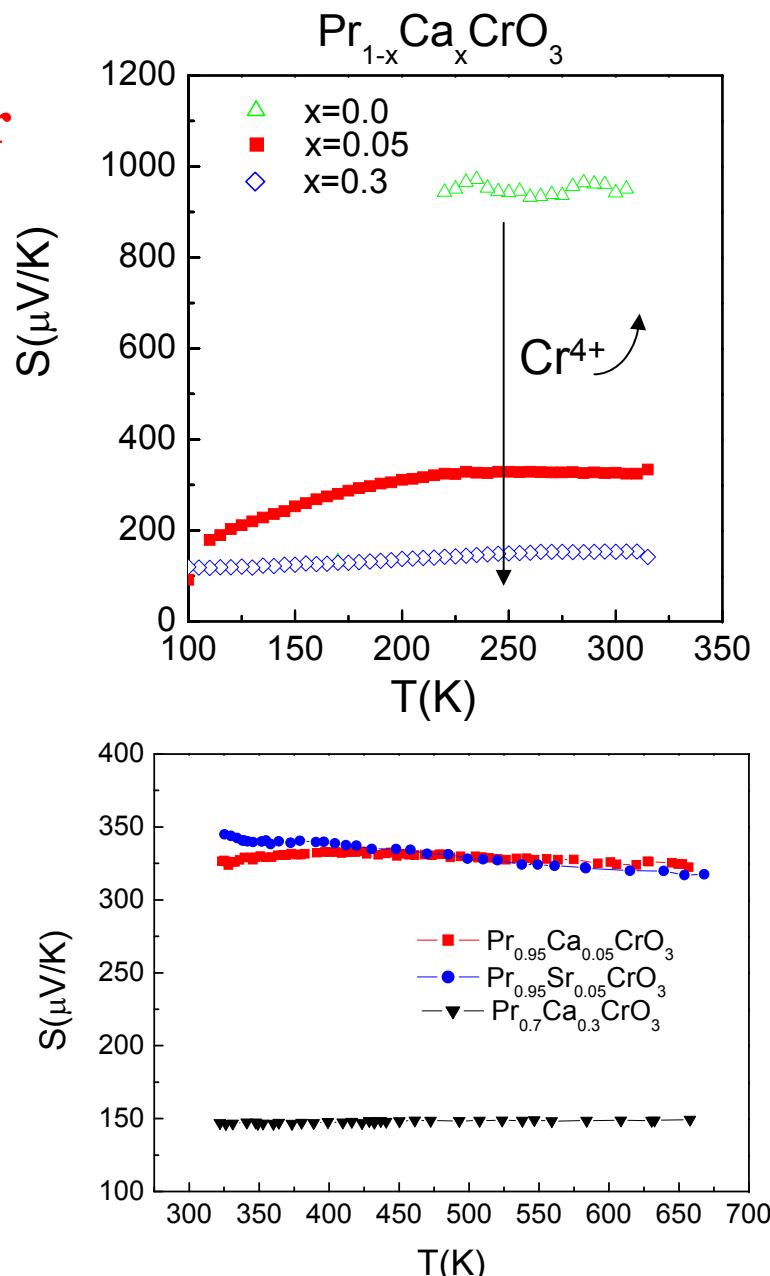
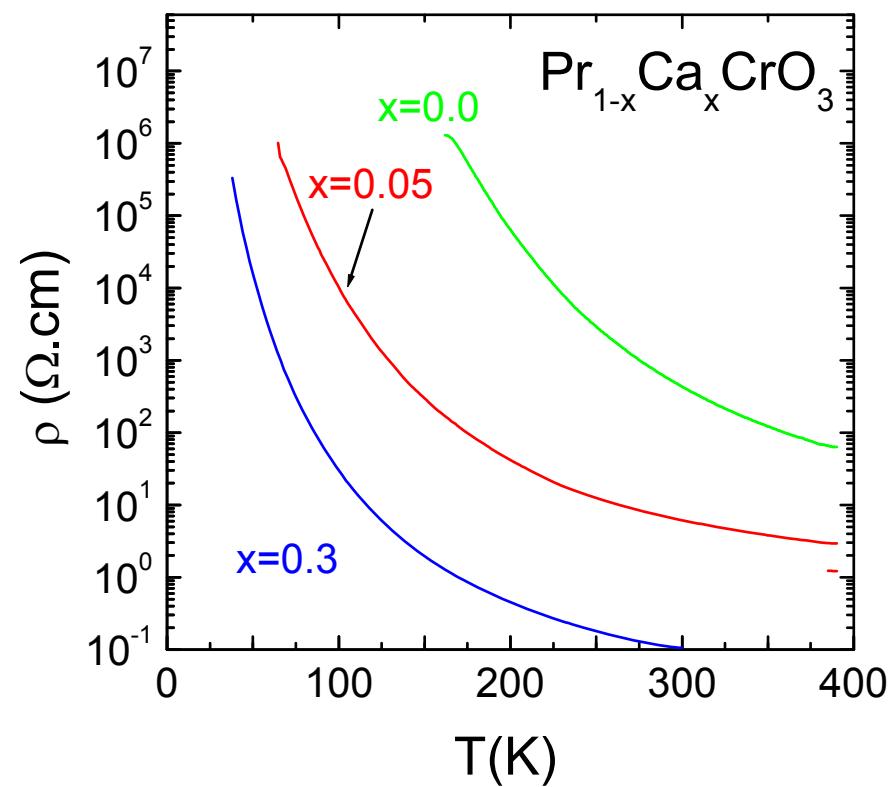
Octaèdres liés par les sommets
(≠ liés par les arêtes)



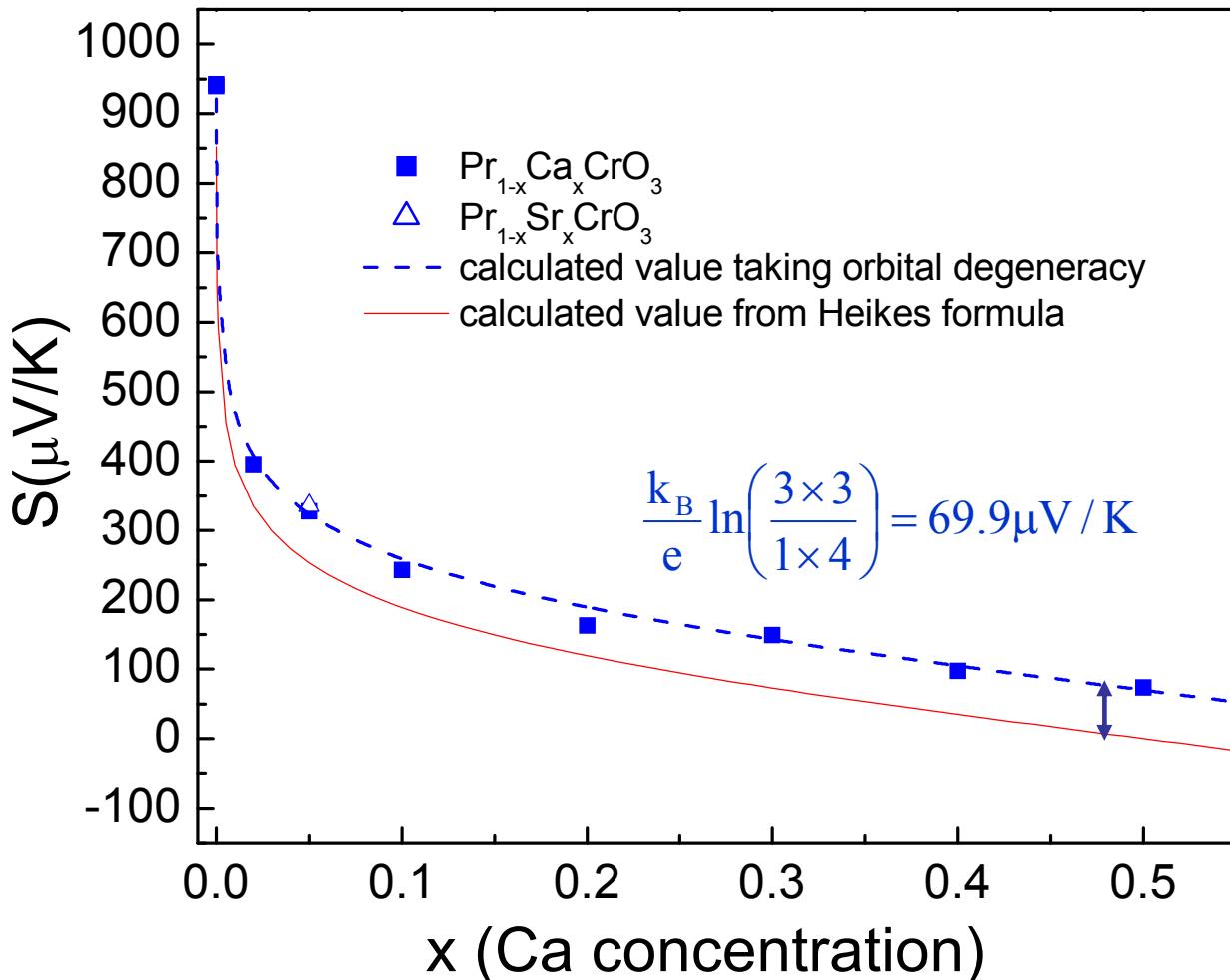
Métallicité
→
Seebeck ≈ 0



Comportement semi-conducteur

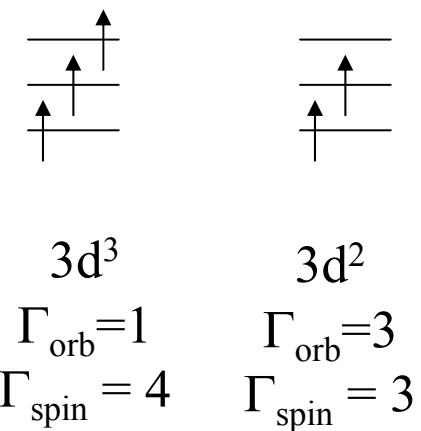


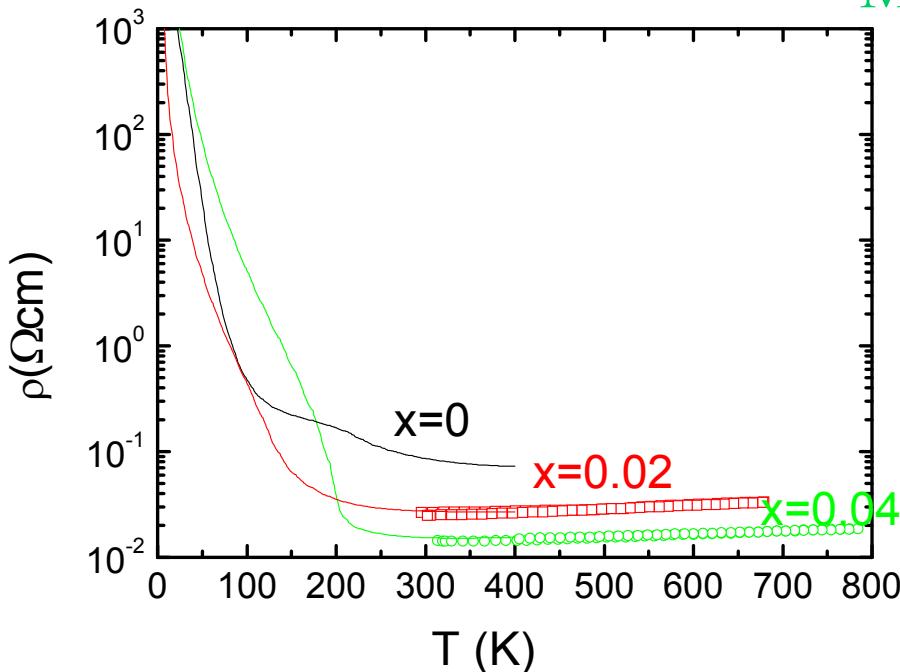
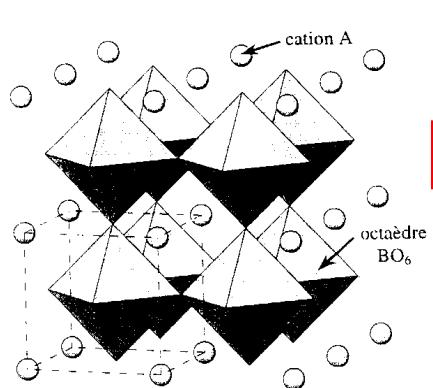
Type p : $Pr_{1-x}Ca_xCrO_3$



$$S = \frac{-k_B}{|e|} \ln\left(\frac{1-x}{x}\right) + \frac{k_B}{|e|} \ln(\Gamma_{\text{orb}} \Gamma_{\text{spin}})$$

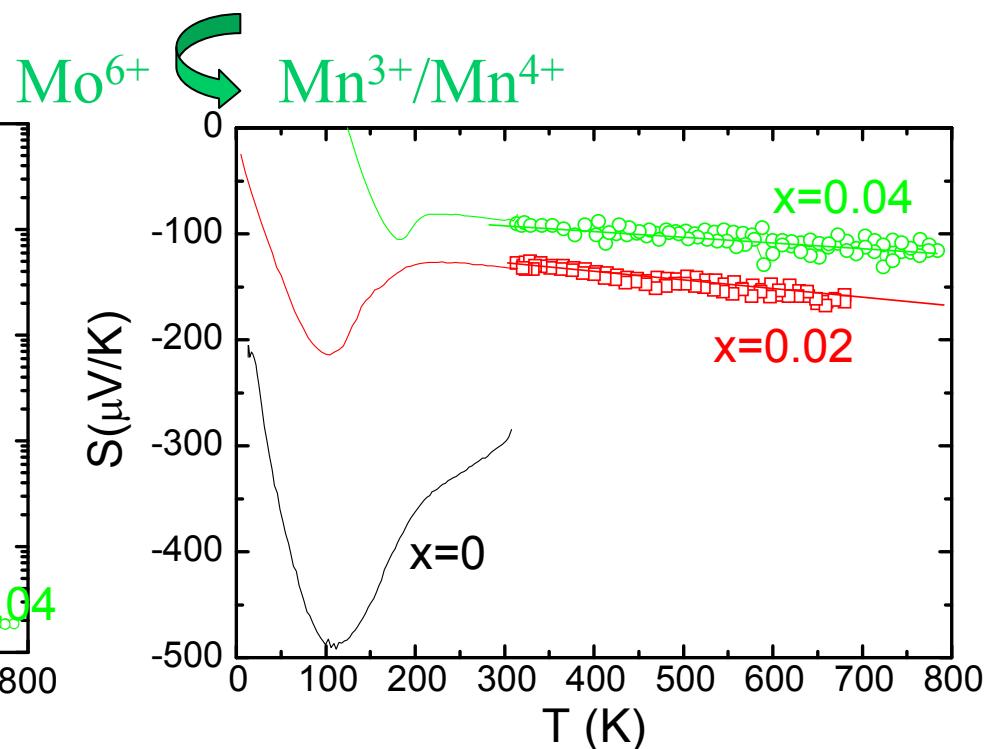
Formule de
Heikes, avec
dégénérescence
de spin et
d'orbitales





n type : Manganese oxides $\text{SrMn}_{1-x}\text{Mn}_x\text{O}_3$

SrMnO_3 : Mn^{4+}

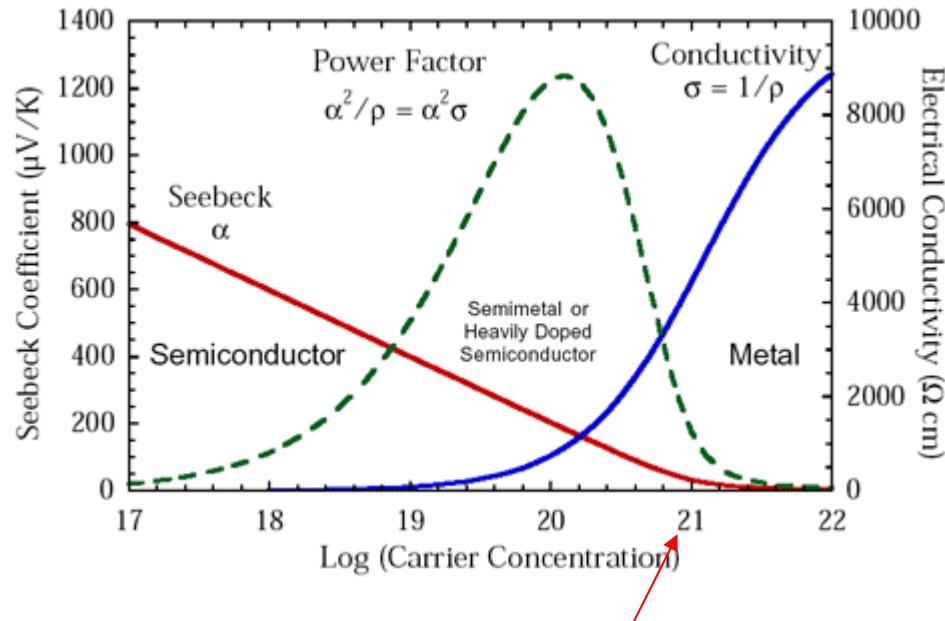


Metallic up to high T / S linear in T : $S = \pi^2 \times k_B / 3e \times k_B T (\partial \ln \sigma(E) / \partial E)$

Power factor increases as T increases :

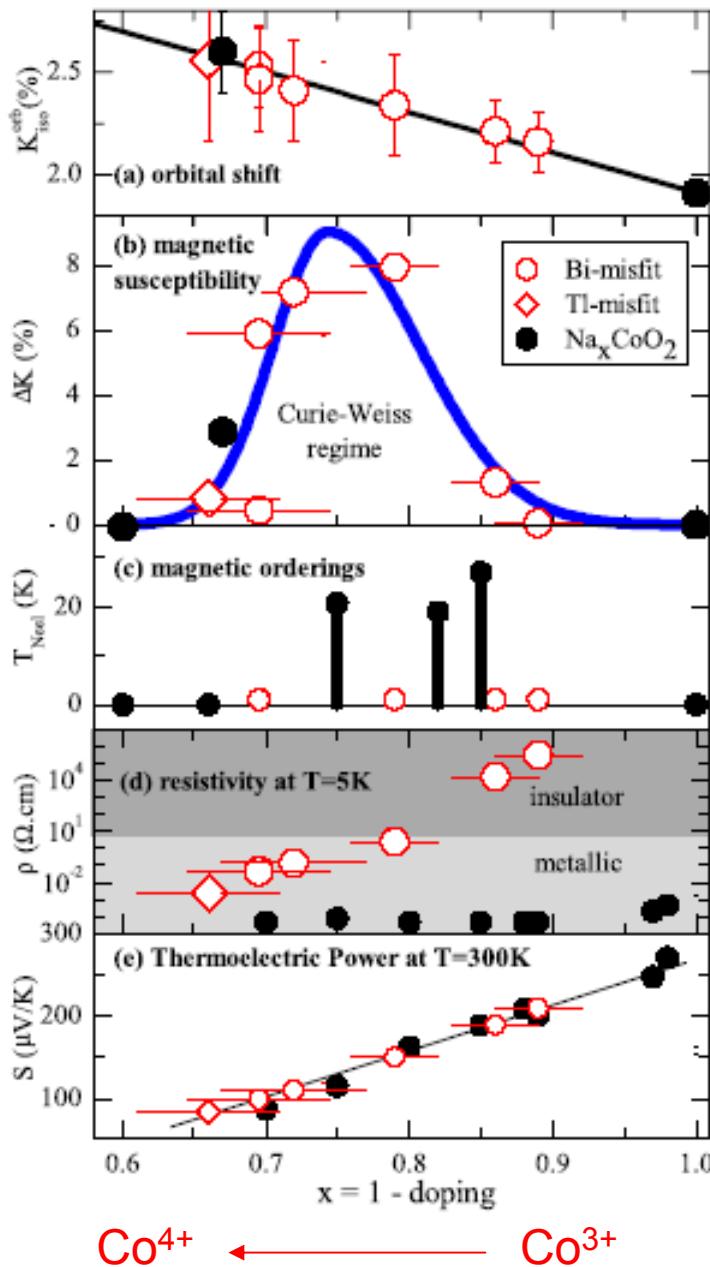
$$\text{PF} = 9.10^{-4} \text{ Wm}^{-1}\text{K}^{-2} \text{ for } x=0.02 \text{ at } 800\text{K}$$

Conclusion



Misfits

- Taux de porteurs élevé $\sim 10^{21} \text{cm}^{-3}$
- Coexistence métallicité + valeur élevée de S
- Formule généralisée de Heikes , avec $\beta = 1/2$



Paramètre misfit

→ Rôle crucial du dopage

$$v_{Co} = 4 - \frac{\alpha}{b_1 / b_2}$$

→ Influence des plans séparateurs?
Résistivité
Conductivité thermique?

Collaborateurs

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